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Furui et al.(10) **Pub. No.: US 2009/0268299 A1**(43) **Pub. Date: Oct. 29, 2009**(54) **ANTI-DAZZLING OPTICAL LAMINATE**(30) **Foreign Application Priority Data**(75) Inventors: **Gen Furui**, Okayama-Ken (JP);
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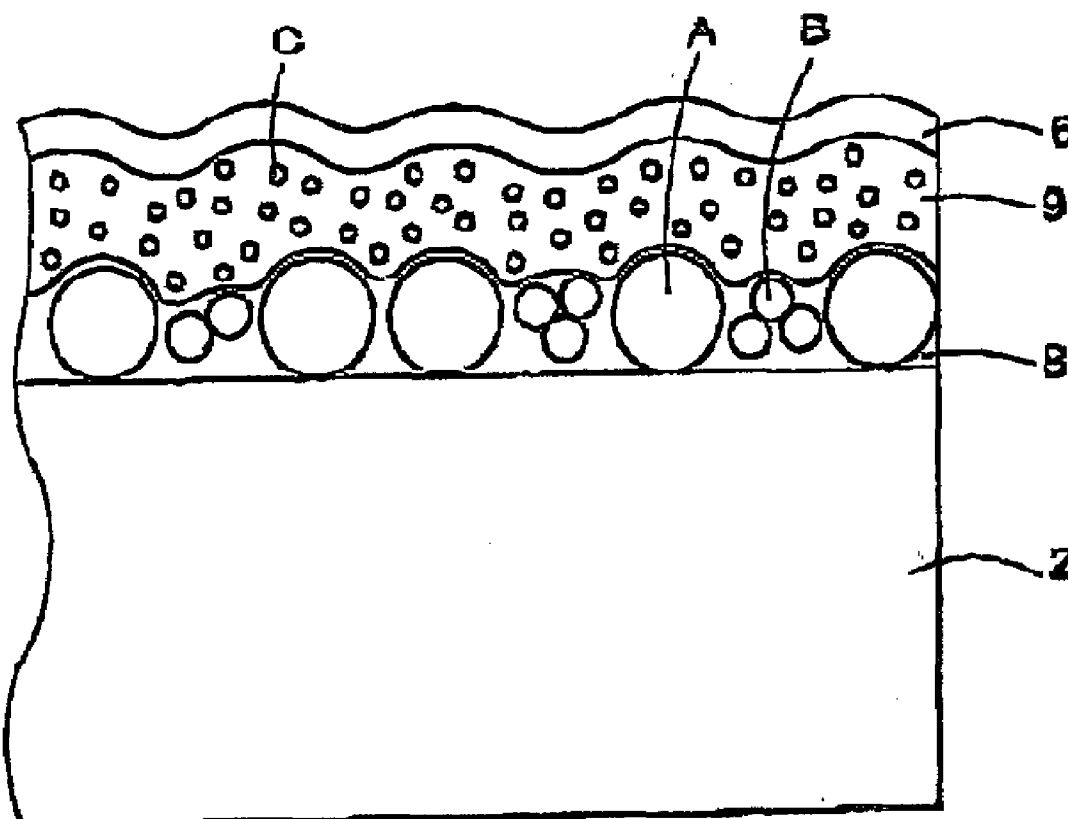
Publication Classification(51) **Int. Cl.**
G02B 1/11 (2006.01)(52) **U.S. Cl.** 359/601(57) **ABSTRACT**

Disclosed is an anti-dazzling laminate which has anti-dazzling properties and can realize excellent glare preventive properties and black color reproducibility (gradation rendering of black color at low brightness). The anti-dazzling laminate is an optical laminate comprises a light transparent base material and an anti-dazzling layer provided on the light transparent base material, wherein the outermost surface of the anti-dazzling layer has a concavoconvex shape, and the optical laminate satisfies the following requirements: Ha is more than 0% and less than 90%, Hi is more than 0% and less than 90%, and Hi/Ha is not less than 0.8 and less than 1.0, wherein Ha represents the whole haze value of the optical laminate; and Hi represents the internal haze value of the optical laminate.

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Shinjuku-Ku (JP)(21) Appl. No.: **12/063,915**(22) PCT Filed: **Aug. 14, 2007**(86) PCT No.: **PCT/JP2007/065837**

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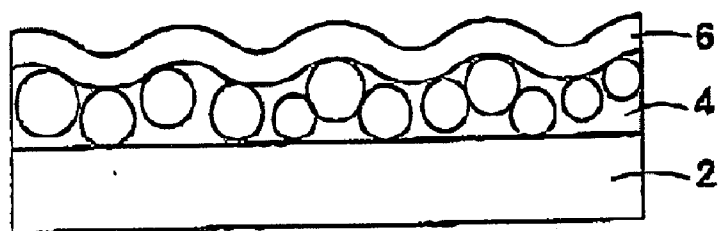


Fig 1.

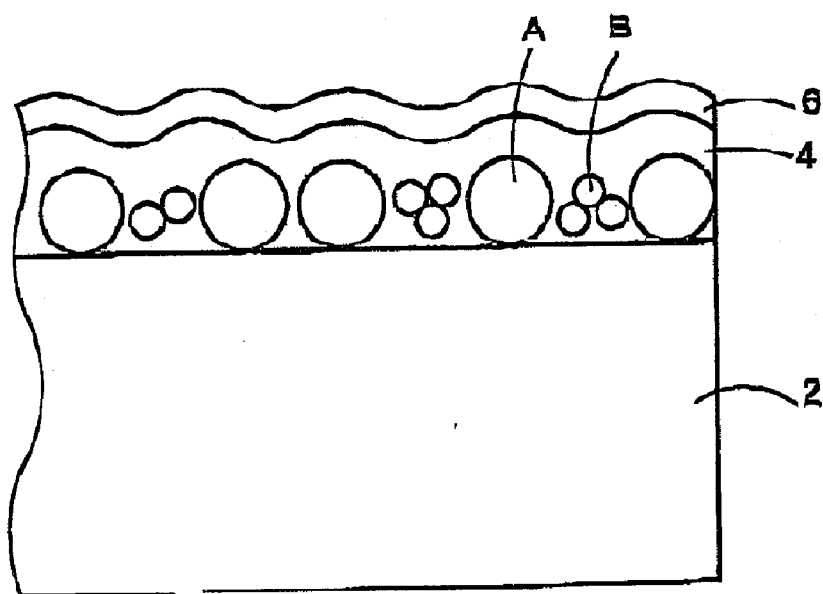


Fig 2.

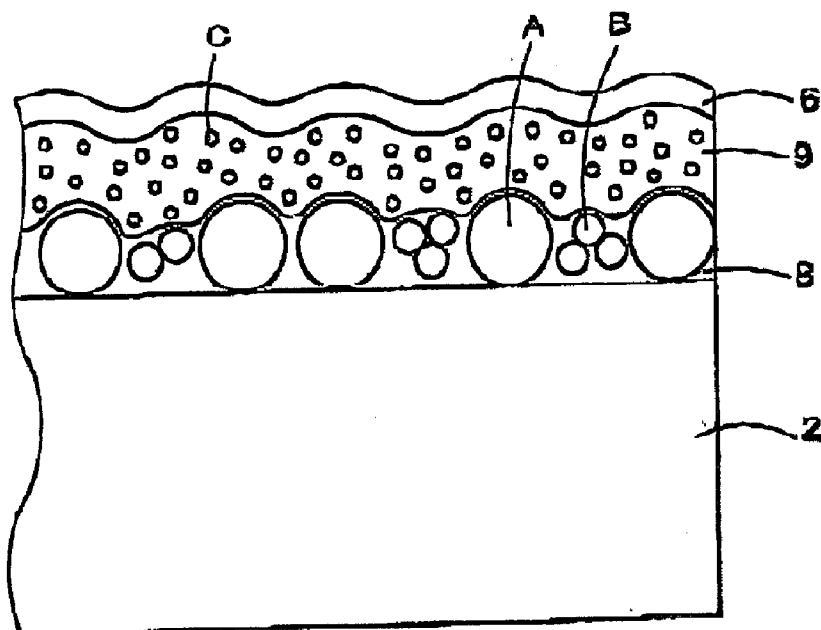
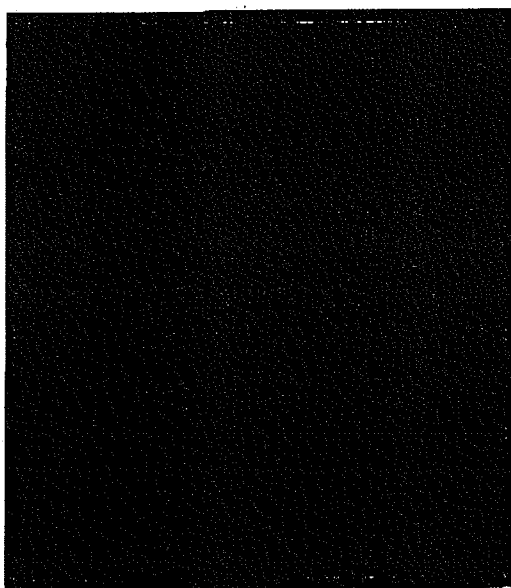


Fig 3.

THE PRESENT INVENTION



PRIOR ART

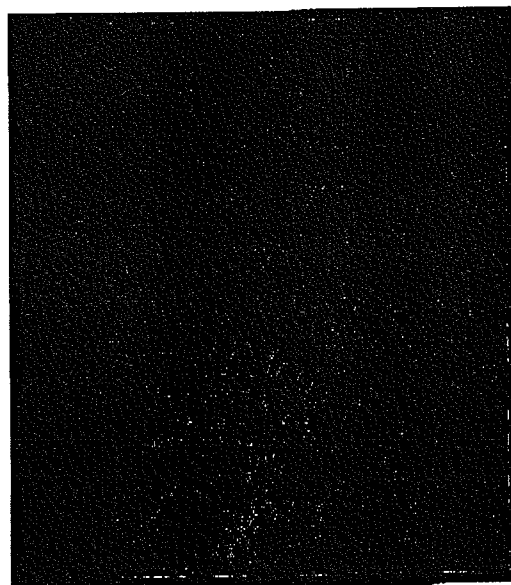


Fig 4.

ANTI-DAZZLING OPTICAL LAMINATE

RELATED APPLICATION

[0001] This application is based upon and claims the benefit of priority from the prior Japanese Patent Application No. 221193/2006 under the Paris Convention, and, thus, the entire contents of the basic application are incorporated herein by reference.

TECHNICAL FIELD

[0002] The present invention provides an anti-dazzling optical laminate for use in displays such as CRTs, PDPs, and liquid crystal panels.

BACKGROUND ART

[0003] The prevention of lowered contrast and lowered visibility caused by external light reflection or image reflection is required of image display devices, for example, cathode-ray tube display devices (CRTs), plasma displays (PDPs), electroluminescent displays (ELDs), or liquid crystal displays (LCDs). Accordingly, it is common practice to provide an antireflection laminate on the outermost surface of an image display device from the viewpoint of reducing image reflection or reflectance using the principle of light scattering or the principle of optical interference.

[0004] In image display devices, for example, liquid crystal displays, the use of an anti-dazzling laminate as one of antireflection laminates has hitherto been known for regulating optical properties to realize excellent image displays. The anti-dazzling laminate is utilized for preventing a lowering in visibility as a result of external light reflection or image reflection within image display devices. The anti-dazzling laminate is generally realized by forming an anti-dazzling layer having a concavoconvex shape on a base material. The anti-dazzling laminate is utilized for preventing a lowering in visibility as a result of external light reflection or image reflection within image display devices.

[0005] In recent years, a demand for a higher level of definition of panel resolution has led to a higher level of fineness of the concavoconvex shape of the anti-dazzling layer. Accordingly, a concavoconvex shape having a broad and large curve has been regarded as unsuitable for meeting a demand for higher definition in the anti-dazzling laminate having the above construction and thus have not been adopted. On the other hand, when increasing the fineness of the concavoconvex shape involved in higher definition of panel resolution can meet a demand for higher definition of the panel resolution. Regarding this technique, however, it has often been pointed out that external light is reflected from the display surface resulting in such a phenomenon that, for example, the image display surface is seen white (whitening), or lowered contrast.

[0006] When the anti-dazzling laminate is used on the image display surface of notebook computers and the like, a certain level of satisfactory optical properties can be provided. When the light transmitted through the backside of backlight within a display is transmitted through the concavoconvex shape face of the anti-dazzling laminate formed on the outermost surface of the panel, however, the concavoconvex shape functions as Fine lenses which disturb the displayed pixels and the like, that is, "glare," is likely to occur. This unfavorable phenomenon makes it difficult to attain the effect of the anti-dazzling laminate per se. In particular, the

occurrence of the "glare" increases with increasing the definition of the panel resolution, and, thus, effectively preventing this unfavorable phenomenon of 'glare' has been desired.

[0007] In order to eliminate this "glare," for example, a method has been adopted in which surface concavoconvexes are densely provided to enhance the sharpness and, at the same time, scattering particles different from the resin for anti-dazzling layer formation in refractive index are added to, for example, impart internal scattering effect to the anti-dazzling laminate. All of proposed methods could satisfactorily solve the problem of the "glare," but on the other hand, they sometimes lowered the visibility of the whole image. On the other hand, in the anti-dazzling laminate, the method for preventing the "glare" in high-definition panels has been regarded as a main cause of an unfavorable phenomenon, for example, a deterioration in contrast such as clouding caused by surface whitening, internal scattering effect or the like. That is, it has been regarded that 'glare prevention' and "contrast improvement" are in the relationship of tradeoff, and simultaneously meeting both the requirements is difficult. In the above methods, for example, black color reproduction including glossy black feeling (wet glossy black color) in on-screen display, contrast and the like have sometimes been poor. That is, gradation rendering of black color in a light room, particularly a black color gradation difference in low gradation, cannot be regarded without difficulties resulting in lowered sensitivity. Specifically, black and gray colors are only recognized as a blurred and identical color-tone black color. In particular, an anti-dazzling laminate having better anti-glare properties has a significantly lowered level of visibility.

[0008] On the other hand, in a method for preventing reflection by light interference, means for regulating the refractive index and layer thickness of each layer known in the art is, for example, to increase the refractive index of a hard coat layer having a clear and smooth outermost surface and then to provide a low-refractive index layer on the hard coat layer. According to this method, a good contrast and a lowest possible reflectance can be realized (for example, to approximately 0.1 to 0.8% in terms of reflection Y value), and reflection of an image of an external material from the surface of a display screen can be effectively prevented. This method, however, has many problems regarding production, for example, difficulties of film thickness regulation of the coating film, and many of necessary materials are expensive. Accordingly, this method is unsuitable for mass production at low cost. Although the reflectance can be minimized, in some environment where a display is viewed, image reflection cannot be satisfactorily prevented. For example, in a room having a white wall, in some cases, a phenomenon of white image reflection occurs when the surface of the white wall is smooth. Further, the reflectance can be lowered by light interference. In this case, however, interference color occurs, and, in some cases, white and black of the display screen are changed to a reddish or bluish color. On the other hand, when the reflectance is not very low, since the outermost surface is smooth, effectively preventing the image reflection is very difficult.

[0009] On the other hand, a light diffusion layer having light diffusion properties improved by bringing the ratio between the internal haze and the whole haze to 2 to 1000 and bringing the internal haze to not less than 59% has hitherto been proposed (patent document 1; Japanese Patent Laid-Open No. 295729/1999). Further, an anti-dazzling laminate is proposed in which glare preventive effect and white blurring

preventive effect can be effectively attained by bringing the whole haze value to not less than 35% and not more than 50%, bringing the internal haze value to not less than 20% and not more than 40%, and bringing the internal haze value/whole haze value to not less than 0.5 and not more than 0.8 (patent document 2: U.S. Pat. No. 3,703,133). According to studies by the present inventors, however, any anti-dazzling laminate, which can prevent glare feeling and can satisfactorily reproduce glossy black feeling of images in a light room, has not been developed yet. Further, in an antireflection film formed by coating a composition comprising a binder and an inorganic filler, the brightness and resolution of transmitted images are deteriorated. To eliminate this drawback, an anti-dazzling laminate produced by forming a filler-free organic surface curing transparent film, covering a concavoconvex mat on the organic surface curing transparent film, and curing the organic surface curing transparent film (patent document 3: Japanese Patent Laid-Open No. 019301/1989) has been developed. In this anti-dazzling laminate, all of concaves and convexes are undulate although the shape is a continuous sine curve. Accordingly, no flat part is present, and, in this concavoconvex shape, desired black reproduction and glassy black feeling cannot be realized.

[0010] Accordingly, at the present time, the development of an optical laminate, which can effectively prevent the glare of an image surface and, at the same time, can realize good anti-dazzling properties and black color reproduction, especially glossy black feeling, has been desired. In particular, an optical laminate, which can be used in liquid crystal displays (LCDs) as well as in other applications such as cathode ray tube display devices (CRTs), plasma displays (PDPs), electroluminescent displays (ELDs), fluorescent display tubes, and field emission-type displays, has been eagerly desired.

[0011] [Patent document 1] Japanese Patent Laid-Open No. 295729/1999

[0012] [Patent document 2] U.S. Pat. No. 3,703,133

[0013] [Patent document 3] Japanese Patent Laid-Open No. 019301/1989

DISCLOSURE OF INVENTION

[0014] At the time of the present invention, the present inventors have found that it is possible to provide an optical laminate which, while imparting anti-dazzling properties, can realize the so-called glossy black feeling (wet glossy black color) by improving the anti-glare property and the contrast, especially improving black color reproduction. The present invention has been made based on such finding.

[0015] Accordingly, the present invention provides an optical laminate which can realize an anti-dazzling function, an excellent anti-glare property, and excellent black color reproduction and, at the same time, can realize image display having a high level of visibility.

[0016] According to the present invention, there is provided an optical laminate comprising a light transparent base material and an anti-dazzling layer provided on the light transparent base material, wherein

[0017] the outermost surface of the anti-dazzling layer has a concavoconvex shape.

[0018] H_a is more than 0% and less than 90%,

[0019] H_i is more than 0% and less than 90%, and

[0020] H_i/H_a is not less than 0.8 and less than 1.0,

[0021] wherein H_a represents the whole haze value of the optical laminate; and H_i represents the internal haze value of the optical laminate.

[0022] The optical laminate according to the present invention can realize excellent anti-dazzling properties and black color reproduction having glossy black feeling, can realize a high level of sharpness and excellent contrast, anti-glare property, and letter blurring preventive property, and can be used in various displays. In particular, the optical laminate according to the present invention can provide an optical laminate which is significantly improved in black color gradation rendering (glossy black color reproduction) in a light room, which could not have been realized by the conventional anti-dazzling laminate without difficulties. More specifically, it is possible to provide an optical laminate which, in an image in movie display, can render gradation substantially comparable with a conventional display provided with only a laminate comprising a flat clear hard coat layer free from any concavoconvex shape, or comprising a clear hard coat layer and an antireflection layer and, at the same time, can realize a good sharpness of the contour of letters and can prevent scintillation. In particular, the optical laminate according to the present invention is advantageous in that images which are significantly improved in black color gradation rendering (glossy black color reproduction) in a light room can be provided.

[0023] In a preferred embodiment of the present invention, the anti-dazzling layer may be formed in a single layer structure. Alternatively, the anti-dazzling layer may be formed by forming a surface modifying layer on a substrate concavoconvex layer having a concavoconvex shape. Further, another optical function layer may be stacked on the anti-dazzling layer having a single layer structure or the surface modifying layer. In the anti-dazzling optical laminate having the above construction, a fine concavoconvex shape may be sealed in such a state that a concavoconvex shape mainly having a smooth and gentle waviness is present whereby desired anti-dazzling properties can be exhibited. As a result, when the surface modifying layer is formed, the anti-dazzling optical laminate can impart various functions such as antistatic properties, hardness regulation, refractive index regulation, and contamination prevention to the optical laminate. In the preferred embodiment of the present invention, the expression "a concavoconvex shape having a smooth and gentle waviness" as used herein means that, unlike the concavoconvex shape in the prior art which always draws a wavy sine curve, the convex part has a large and smooth shape and a part between the convexes has a shape very close to "a flat shape" rather than the concave shape. In a preferred embodiment of the present invention, the presence of the concavoconvex shape can realize better anti-dazzling properties and a high level of black color reproduction having a glossy black feeling.

[0024] The present invention will be described in conjunction with FIG. 4 for easily understanding the details of the preferred concavoconvex shape. FIG. 4 shows optical microphotographs (reflection photographing; magnification: 20 times; upper diagram) of a preferred concavoconvex shape (left) in the present invention and a conventional concavoconvex shape (right), and a typical diagram of a sectional concavoconvex shape (lower diagram). From the optical photomicrographs shown in FIG. 4, it is understood that, unlike the conventional concavoconvex shape (right), the concavoconvex shape (left) of the present invention has a gentle flat part. Further, according to the typical diagram of a sectional concavoconvex shape in FIG. 4, the angle of the bottom (flat part) in the concave part in the present invention to the tangential line to the profile peak of the convex part is very small. On the

other hand, as can be seen from the optical photomicrographs and the typical diagram of sectional concavoconvex shape in FIG. 4, unlike the present invention, the conventional concavoconvex shape (right) is substantially free from any flat part, and the concavoconvex shape continues smoothly. In this shape, very excellent anti-dazzling properties can be realized, but on the other hand, since all the concavoconvexes are in a curve form, light is diffused in every part resulting in unsatisfactory glossy black feeling.

BRIEF DESCRIPTION OF THE DRAWINGS

[0025] FIG. 1 is a schematic cross-sectional view of an optical laminate according to the present invention.

[0026] FIG. 2 is a schematic cross-sectional view of an optical laminate according to the present invention.

[0027] FIG. 3 is a schematic cross-sectional view of an optical laminate according to the present invention.

[0028] FIG. 4 is a diagram showing optical photomicrographs and a typical diagram of a sectional concavoconvex shape which compare the concavoconvex shape (anti-dazzling layer) of the present invention and the conventional concavoconvex shape (anti-dazzling layer).

BEST MODE FOR CARRYING OUT THE INVENTION

I. Definition

[0029] Resin

[0030] Curable resin precursors such as monomers, oligomers, and prepolymers are collectively defined as "resin," unless otherwise specified.

[0031] Surface Haze (Hs), Internal Haze (Hi), and Whole Haze (Ha)

[0032] The term "surface haze (Hs)" as used herein is determined as follows. A proper mixture of an acrylic monomer such as pentaerythritol triacrylate with other oligomer or polymer is diluted with methyl ethyl ketone, toluene, or a mixed solvent composed of the above solvents or the like to a solid content of 60%, and the diluted solution is coated with a wire bar onto concavoconvexes of the anti-dazzling layer to a thickness on a dry film basis of 8 μm , whereby the surface concavoconvexes of the anti-dazzling layer are rendered flat. In this case, when the recoating agent is likely to be repelled and less likely to wet the anti-dazzling layer due to the presence of a leveling agent in the composition for anti-dazzling layer formation, a method may be adopted in which the anti-dazzling film is previously rendered hydrophilic by saponification. The saponification is carried out by immersing the anti-dazzling layer in a 2 mol/liter NaOH (or KOH) solution (55° C.) for 3 min, washing the film with water, completely removing water droplets with a Klmwipe and the like, and then drying the film in an oven (50° C.) for one min. The optical laminate having a flattened surface in the anti-dazzling layer does not have any haze derived from surface concavoconvexes but has only an internal haze. This haze can be determined as an internal haze (Hi). The value obtained by subtracting the internal haze (Hi) from the original optical laminate haze (whole haze (Ha)) is determined as a surface haze (Hs) attributable only to surface concavoconvexes.

[0033] Haze Value, 60-Degree Gloss, and Transmission Sharpness

[0034] The haze value may be measured according to JIS K 7136. A reflection-transmittance meter HM-150 (Murakami Color Research Laboratory) may be mentioned as an instru-

ment used for the measurement. The total light transmittance of the anti-dazzling laminate may be measured with the same measuring device as in the haze value according to JIS K 7361. The haze and total light transmittance are measured in such a state that the coated face is directed to a light source. The 60-degree gloss can be measured with a precision gloss meter (GM-26D, manufactured by Murakami Color Research Laboratory) according to JIS Z 8741. The 60-degree gloss is measured in such a state that, in order to eliminate the influence of backside reflection of a sample, a double face adhesive tape (manufactured by Teraoka Seisakusho Co., Ltd.) is applied to the backside of a sample and a black lid of the measuring device. The transmission sharpness is expressed in terms of the total of numerical values obtained by measurement with five types of optical combs (0.125 mm, 0.25 mm, 0.5 mm, 1 mm, and 2 mm) with an image clarity measuring device (stock number, "ICM-1DP", manufactured by Suga Test Instruments Co., Ltd.) according to JIS K 7105.

[0035] Average Spacing of Profile Irregularities (concavoconvexes) S_m (μm), Average Inclination Angle θ_a (degree) and R_z (μm)

[0036] The anti-dazzling layer constituting the optical laminate according to the present invention has a concavoconvex shape. S_m (μm) represents the average spacing of concavoconvexes (profile irregularities) of the anti-dazzling layer, and θ_a (degree) represents the average inclination angle of the concavoconvex part. S_m (μm) and θ_a (degree) may be defined as described in an instruction manual (revised on Jul. 20, 1995) of a surface roughness measuring device (model: SE-3400, manufactured by Kosaka Laboratory Ltd.) in conformity with JIS B 0601 1994. θ_a (degree) represents the angle mode, and, when the inclination is Δa in terms of aspect ratio, $\Delta a = \tan \theta_a$ is established (sum of differences (corresponding to the height of each convex) between the minimum part and the maximum part in each concavoconvex/reference length). The "reference length" is the same as in the following measuring conditions and is the measured length (cut-off value λ_c) which has been actually measured with a stylus by SE-3400.

[0037] Measurement

[0038] In the measurement of the parameters (S_m , θ_a , and R_z) representing the surface roughness of the optical laminate according to the present invention, for example, the above surface roughness measuring device is provided. According to JIS B 0601 1994, the reference length and the evaluation length are selected, and the measurement is carried out under measuring conditions for the surface roughness measuring device. This measuring method is favorable in the present invention.

[0039] 1) Tracer in Surface Roughness Detector:

[0040] Model/SE2555N (standard 2 μm), manufactured by Kosaka Laboratory Ltd. (radius of curvature in tip 2 μm /apex angle: 90 degrees/material: diamond)

[0041] 2) Measuring Conditions for Surface Roughness Measuring Device:

[0042] Reference length (cut-off value of roughness curve λ_c):

1] 0.25, 2] 0.8, 3] 1.25, or 4] 2.5 mm

[0043] Evaluation length (reference length (cut-off value λ_c) $\times 5$):

1] 1.25, 2] 4.0, 3] 6.25, or 4] 12.5 mm

[0044] Feed speed of tracer: 0.1 to 0.5 mm/sec (when reference lengths are 1] to 4], the corresponding evaluation lengths are 1] to 4])

[0045] Reflection γ value

[0046] The reflection γ value is defined in JIS Z 2822 and is a value indicating a luminous reflectance determined by measuring 5-degree regular reflectance in a wavelength range of 380 to 780 nm with a spectrophotometer MPC 3100 manufactured by Shimadzu Seisakusho Ltd. and then converting the reflectance values to lightness which can be perceived by the human eye with a software (Incorporated in MPC 3100). The 5-degree regular reflectance is measured in such a state that, in order to prevent the backside reflection of the optical laminate, a black tape (manufactured by Teraoka Seisakusho Co., Ltd.) is applied to the side remote from the film face to be measured.

[0047] Glossy Black Feeling in Light Room

[0048] The glossy black feeling is evaluated by visually observing an assembly comprising an optical laminate provided on a panel which displays a black color under a light room environment. When the reflection angle of light incident on the optical laminate is wide (as in the case of a conventional anti-dazzling layer having concavoconvexes), light is reflected in all directions (diffusion reflected) depending upon the angle of concavoconvexes on the surface of the optical laminate and then reaches the viewer's eye, making it impossible to reproduce the original black color. That is, only a part of the diffused light reaches the viewer's eye. On the other hand, when the incident light is intensively reflected to a part around regular reflection angle (as in an anti-dazzling layer of the present invention which has a gentle concavoconvex shape and has a substantially flat concave part), light from a light source is not substantially diffusion reflected and is brought to regularly reflected light. Since light other than the regularly reflected light does not reach the viewer's eye, the original wet black color can be reproduced. This original black color is described as glossy black feeling.

[0049] Total Thickness of Anti-Dazzling Layer

[0050] The total thickness of the anti-dazzling layer refers to a part extended from the base material on its display surface side interface to the outermost surface of the anti-dazzling concavoconvex in contact with the air. In the part extended from the base material interface to the outermost surface, the anti-dazzling layer has either a single layer or a multilayer structure comprising a surface modifying layer and other optical function layers stacked onto the substrate concavoconvex layer.

[0051] Method for Measuring Total Layer Thickness

[0052] The total layer thickness can be measured by transmission observation of the cross-section of the optical laminate under a confocal laser microscope (LeicaTCS-NT, manufactured by Leica: magnification "300 to 1000 times") to determine whether or not the interface is present, and determining the thickness according to the following measurement standard. Specifically, in order to provide a halation-free sharp image, a wet objective lens was used in a confocal laser microscope, and about 2 ml of an oil having a refractive index of 1.518 was placed on an optical laminate, followed by observation to determine the presence or absence of the interface. The oil was used to allow the air layer between the objective lens and the optical laminate to disappear.

[0053] Measurement Procedure

[0054] 1: The average thickness of the layer was measured by observation under a laser microscope.

[0055] 2: The measurement was carried out under the above conditions.

[0056] 3: For one image plane, the layer thickness from the base material to the maximum profile peak (convex) part in the concavoconvexes was measured for one point, and the layer thickness from the base material to the minimum valley (concave) part in the concavoconvexes was measured for one point. That is, the layer thickness was measured for two points in total for one image plane. This measurement was carried out for five image planes, that is, 10 points in total, and the average value was determined and was regarded as the total layer thickness. In this laser microscope, by virtue of the difference in refractive index between the layers, nondestructive cross-sectional observation can be carried out. Accordingly, likewise, if the refractive index difference is unclear or is a value close to 0 (zero), then the thickness of the anti-dazzling layer and the surface-modifying layer can be determined by observation of five image planes using observation of the cross-sectional photographs of SEM and TEM observable by the difference in composition between the layers in the same manner as described above.

[0057] II, Optical Laminate

[0058] Properties

[0059] 1) Haze Value

[0060] The optical laminate according to the present invention satisfies all the following numerical value requirements. In the following numerical value requirements, Ha represents the whole haze value of the optical laminate; and Hi represents the internal haze value of the optical laminate. Hs represents the surface haze value of the optical laminate.

[0061] Ha is more than 0% and less than 90%. Preferably, the lower limit of Ha is 0.3%, more preferably 3%, and upper limit of Ha is 85%, more preferably 70%.

[0062] Hi is more than 0% and less than 90%. Preferably, the lower limit of Hi is 0.1%, preferably 1.0%, and the upper limit of Hi is 85%, preferably 70%, more preferably 55%. When the Ha and Hi values are less than 90%, the productivity of the anti-dazzling layer is high. Further, the outermost surface of actual displays provided with the anti-dazzling layer has excellent internal diffusion properties, and any white image possessed by the display surface per se does not appear. As a result, satisfactory glossy black feeling can be realized.

[0063] Hi/Ha is not less than 0.8 and less than 1.0. Preferably, the lower limit of Hi/Ha is 0.85, more preferably 0.9, and upper limit of Hi/Ha is preferably 0.98. The surface haze Hs caused by surface irregularities is brought to the above-defined range which does not lose the anti-dazzling properties, and the internal haze Hi caused by the internal diffusion effect attained by the difference in refractive index between the resin and the fine particles is regulated to the above-defined range. The above regulation can realize the production of preferred optical laminates which exhibit optical properties optimal for modes in liquid crystal, PDP, CRT, ELD and other panels.

[0064] In a preferred embodiment of the present invention, Hs is not less than 0.1 and less than 6.0. Preferably, the lower limit of Hs is 0.3, and the upper limit of Hs is 5%.

[0065] 2) Sm, θ_a , and Rz

[0066] The optical laminate according to the present invention preferably satisfies the following numerical value requirements. In the following numerical value requirements, Sm represents the average spacing of concavoconvexes or profile irregularities in the anti-dazzling layer; θ_a represents the average inclination angle of the concavoconvexes or profile irregularities; and Rz represents the average roughness of

the concavoconvexes or profile irregularities. In a preferred embodiment of the present invention, when S_m , θ_a and Z_m values are brought to the following respective numerical value ranges, as shown in FIG. 4 (left), the convexes in the concavoconvex shape are rendered coarse and, consequently, black color reproduction having glossy black feeling can be realized on a higher level.

[0067] S_m is not less than 50 μm and not more than 500 μm . Preferably, the lower limit of S_m is 60 μm , and the upper limit of S_m is 400 μm .

[0068] θ_a is not less than 0.1 degree and not more than 1.2 degrees. Preferably, the lower limit of θ_a is 0.3 degree, and the upper limit of θ_a is 0.9 degree.

[0069] R_z is more than 0.2 μm and not more than 1.2 μm . Preferably, the lower limit of R_z is 0.3 μm , and the upper limit of R_z is 1.0 μm .

[0070] Layer Construction

[0071] The optical laminate according to the present invention will be described with reference to FIG. 1. FIG. 1 is a cross-sectional view of an optical laminate according to the present invention. An anti-dazzling layer 4 is provided on the upper surface of a light transparent base material 2. In a preferred embodiment of the present invention, the anti-dazzling layer 4 contains two or more types of fine particles having large and small sizes. Further, an optical laminate comprising an anti-dazzling layer 4 and a low-refractive index layer 6 having a lower refractive index than the anti-dazzling layer 4 provided on the surface of the anti-dazzling layer 4 is preferred.

[0072] Another embodiment of the optical laminate according to the present invention will be described with reference to FIG. 2. FIG. 2 is a cross-sectional view of an optical laminate according to the present invention. An anti-dazzling layer 4 is provided on the upper surface of the light transparent base material 2. In a preferred embodiment of the present invention, the anti-dazzling layer 4 comprises first fine particles A and second fine particles B (which may be coagulated) or comprises the above two types of fine particles A and B and third fine particles (which may be coagulated). The anti-dazzling layer 4 comprises a substrate concavoconvex layer 8 and a surface modifying layer 9. The substrate concavoconvex layer 8 may be formed in the same manner as in the anti-dazzling layer 4 described in connection with FIG. 1. In a preferred embodiment of the present invention, the optical laminate comprises a surface modifying layer 9 and a low-refractive index layer 6 having a lower refractive index than the surface modifying layer 9 provided on the surface modifying layer 9. Accordingly, it is understood that the anti-dazzling layer according to the present invention may be one having a single-layer structure or one comprising a substrate concavoconvex layer and a surface modifying layer provided on the substrate concavoconvex layer. Accordingly, in the present invention, the "anti-dazzling layer" as used herein means both an anti-dazzling layer having a single-layer structure (not provided with a substrate concavoconvex layer) or an anti-dazzling layer comprising a substrate concavoconvex layer, a surface modifying layer, and optionally an optical function layer. Both the anti-dazzling layer and the substrate concavoconvex layer may be formed by substantially the same material and forming method.

[0073] An optical laminate in a further embodiment of the present invention will be described in conjunction with FIG. 3. FIG. 3 is a cross-sectional view of an optical laminate according to the present invention. In this optical laminate, an

anti-dazzling layer 4 which functions also as a substrate concavoconvex layer 8 and a surface modifying layer 9 is provided on the upper surface of a light transparent base material 2. In a preferred embodiment of the present invention, the substrate concavoconvex layer 8 comprises first fine particles A and second fine particles B (which may be coagulated) or comprises the above two types of fine particles A and B and third fine particles (which may be coagulated). Further, preferably, the surface modifying layer 9 comprises a fluidity modifying agent C which is a kind of a surface modifying agent. Furthermore, preferably, a low-refractive index layer 6 having a lower refractive index than the surface modifying layer 9 is formed onto the surface modifying layer 9.

[0074] 1. Anti-Dazzling Layer

[0075] In the present invention, an anti-dazzling layer is provided on the light transparent base material. Preferably, the optical laminate has on its surface an anti-dazzling layer having a concavoconvex shape. The anti-dazzling layer may consist of a resin only. Preferably, the anti-dazzling layer is formed of a resin and fine particles. The thickness H μm of the anti-dazzling layer is not less than 2 μm and not more than 30 μm . Preferably, the lower limit of the layer thickness H μm is 5 μm , and the upper limit of the layer thickness H μm is 25 μm .

[0076] 1) Difference n in Refractive Index of Anti-Dazzling Layer Formed Using Composition for Anti-Dazzling Layer, Comprising Resin and Fine Particles

[0077] In the present invention, the difference n in refractive index between the resin and the fine particles is preferably not more than 0.20. More specifically, the refractive index difference n is not less than 0.05 and not more than 0.20. Preferably, the lower limit of the refractive index difference n is 0.07, more preferably 0.09, and the upper limit of the refractive index difference n is 0.18, more preferably 0.12. When the difference n in refractive index between the resin and the fine particles falls within the above-defined range, the internal haze of the optical laminate can be imparted and uneven image in LCDs and the like and scintillation caused upon the transmission of light such as backlight transmitted through the optical laminate from its backside can be effectively prevented. The term "scintillation" as used herein means a phenomenon seen by the eye as twinkling flickering.

[0078] On the other hand, in another preferred embodiment of the present invention, the difference n in refractive index between the resin and the fine particles is more than 0 and not more than 0.05. The lower limit of the refractive index difference n is preferably 0.001, more preferably 0.005, and the upper limit of the refractive index difference n is preferably 0.03, more preferably 0.01. When the difference n in refractive index between the resin and the fine particles is in the above-defined range, a high contrast and a low haze value can be realized.

[0079] In the present invention, the difference n in refractive index between the resin and the fine particles is defined in the above two range levels. This is not technically contradictory, because the above two range levels are necessary for realizing desired optical properties as the optical laminate, particularly an which the optical laminate of the present invention is mounted, for realizing optical properties optimal for modes in individual liquid crystal, PDP, CRT or other panels.

[0080] Fine Particles

[0081] The fine particles may be in a spherical, for example, truly spherical, elliptical form, or irregular shape, preferably in a truly spherical form. The fine particles may be aggrega-

tion-type fine particles. In the present invention, the average particle diameter R (μm) of the fine particles is not less than 1.0 μm and not more than 20 μm . Preferably, the upper limit of the average particle diameter R is 15.0 μm , more preferably 13.5 μm , and the lower limit of the average particle diameter R is 1.3 μm , more preferably 3.5 μm (still more preferably 4.0 μm). When the average particle diameter R of the fine particles is in the above-defined range, advantageously, a proper concavoconvex shape can be formed, and a preferred thickness range can be realized in the anti-dazzling layer.

[0082] The above average particle diameter is an average particle diameter when the fine particles are monodisperse particles (particles having a single shape). When the particles have a broad particle size distribution, the diameter of particles which occupy the largest proportion of the particles as determined by particle size distribution measurement is regarded as the average particle diameter. The particle diameter of the fine particles may be mainly measured by a Coulter counter method. Further, in addition to the above method, laser diffractometry and SEM photographing may also be adopted.

[0083] In the present invention, not less than 80% (preferably not less than 90%) of the whole fine particles is preferably accounted for by fine particles having an average particle diameter distribution of $R \pm 1.0 \mu\text{m}$, preferably $R \pm 0.5 \mu\text{m}$, more preferably $R \pm 0.3 \mu\text{m}$. When the average particle diameter distribution of the fine particles falls within the above-defined range, the evenness of the concavoconvex shape of the anti-dazzling laminate can be rendered good and, at the same time, scintillation and the like can be effectively prevented. Further, the fine particle system may be such that the above fine particles are used as first fine particles, and a plurality of types of fine particles having an average particle diameter different from the first fine particles, for example, second fine particles, third fine particles or nth fine particles, wherein n is a natural number. For example, for small first fine particles of which the average particle diameter R (μm) is approximately 3.5 μm , a concavoconvex layer can be efficiently formed using fine particles having a particle size distribution with the average particle diameter being 3.5 μm rather than monodisperse fine particles.

[0084] When a plurality of types of fine particles different from each other in average particle diameter are contained, the average particle diameter of each of the second, third and nth fine particles is preferably in the same average particle diameter range as the above fine particles (first fine particles).

[0085] In the present invention, preferably, the fine particles and the resin satisfy a requirement for the total weight ratio per unit area between the fine particles and the resin of m/M = not less than 0.01 and not more than 1.2 wherein m represents the total weight of the fine particles per unit area (when a plurality of types of fine particles are present, the total of each type of fine particles); and M represents the total weight of the resin per unit area. Preferably, the lower limit of the m/M value is 0.012, more preferably 0.015, and the upper limit of the m/M value is 1.0, more preferably 0.3.

[0086] Aggregation-Type Fine Particles

[0087] In the present invention, the use of aggregation-type fine particles among the fine particles may be used. The aggregation-type fine particles may be identical fine particles, or alternatively may be a plurality of types of fine particles different from each other in average particle diameter. Accordingly, when a plurality of types of aggregated fine particles are used, the fine particle system may comprise

(aggregated) first fine particles, and (aggregated) second fine particles, (aggregated) third fine particles, or (aggregated) nth fine particles, wherein n is a natural number, which are different from the first fine particles in average particle diameter. When the (aggregated) second fine particles, (aggregated) third fine particles, or (aggregated) nth fine particles are used, preferably, these particles as such or the aggregated part as such do not exhibit anti-dazzling properties in the anti-dazzling layer. In the case of the aggregation-type fine particles, preferably, the secondary particle diameter falls within the above average particle diameter range.

[0088] Properties and the Like of Fine Parties

[0089] In the present invention, preferably, the fine particles satisfy the following formula:

$$0.25 R (\text{preferably } 0.50) \leq R_2 \leq 1.0 R (\text{preferably } 0.70)$$

wherein R represents the average particle diameter of the first fine particles, μm ; and R_2 represents the average particle diameter of the second fine particles, μm .

[0090] When the R_2 value is not less than 0.25 R, the dispersion of the composition is easy and, consequently, the particles are not aggregated. In the step of drying after coating, a uniform concavoconvex shape can be formed without undergoing an influence of wind during floating. Further, when R_2 value is not more than 1.0 R, advantageously, the function of the first fine particles can be clearly distinguished from the function of the second fine particles. For example, the function of the fine particles can be distinguished so that, when the first fine particles are used for the formation of a concavoconvex shape, the second fine particles function to exhibit the internal diffusion effect or to regulate the dispersibility of the first fine particles in the lateral direction within the film. In this case, the second fine particles are preferably aggregated fine particles. When the third fine particles and the nth fine particles are present, the particle diameter relationship is preferably the same as the relationship between the first fine particles and the second fine particles. In this case, preferably, the second fine particles are R, and the third fine particles are R_2 . The function of the third fine particles may be the same as that of the second fine particles.

[0091] In another embodiment of the present invention, preferably, the total weight ratio per unit area among the resin, the first fine particles, and the second fine particles satisfies requirements represented by the following formula:

$$0.08 \leq (M_1 + M_2) / M \leq 0.38$$

$$0 < M_2 \leq 4.0 M_1$$

wherein M_1 represents the total weight of the first fine particles per unit area; M_2 represents the total weight of the second fine particles per unit area; and M represents the total weight of the resin per unit area.

[0092] In another preferred embodiment of the present invention, preferably, a requirement represented by the following formula is satisfied:

$$\Delta n = |n_1 - n_3| < 0.15 \text{ and/or } \Delta n = |n_2 - n_3| < 0.18$$

[0093] wherein n_1 , n_2 , and n_3 represent the refractive indexes of the first fine particles, the second fine particles, and the resin, respectively.

[0094] The fine particles (first, second, third, and nth fine particles) are not particularly limited. They may be of inorganic type and organic type and are preferably transparent. Specific examples of fine particles formed of an organic material include plastic polymer beads. Plastic beads include sty-

rene beads (refractive index 1.59 to 1.60), melamine beads (refractive index 1.57), acrylic beads (refractive index 1.49 to 1.535), acryl-styrene beads (refractive index 1.54 to 1.58), benzoguanamine-formaldehyde beads, polycarbonate beads, and polyethylene beads. Preferably, plastic bead has a hydrophobic group on its surface, and, for example, styrene beads may be mentioned. For example, amorphous silica may be mentioned as the inorganic fine particle.

[0095] Silica beads having a particle diameter of 0.5 to 5 μm and having good dispersibility are preferred as the amorphous silica. The content of the amorphous silica is preferably 1 to 30 parts by mass based on the binder resin. In this case, the increase in viscosity of the composition for an anti-dazzling layer can be suppressed to render the dispersibility of the amorphous silica good. Further, in the present invention, the surface of the particles may be treated with an organic material or the like. The treatment of the surface of the particles with an organic material is preferably hydrophobization.

[0096] The organic material treatment may be carried out by any of a chemical method in which a compound is chemically bonded to the surface of the bead, and a physical method in which a compound is impregnated into voids or the like present in the composition constituting the bead without chemical bonding to the bead surface. In general, a chemical treatment method utilizing an active group present on silica surface, for example, hydroxyl group or silanol group, is preferably used from the viewpoint of treatment efficiency.

[0097] Specific examples of compounds usable for the treatment include silane-type, siloxane-type, and silazane-type materials highly reactive with the active group, for example, straight-chain alkyl monosubstituted silicone materials such as methyltrichlorosilane, branched alkyl monosubstituted silicone materials, or polysubstituted straight chain alkylsilicone compounds and polysubstituted branched chain alkylsilicone compounds such as di-n-butylchlorosilane and ethyldimethylchlorosilane. Likewise, straight chain alkyl group or branched alkyl group monosubstituted or polysubstituted siloxane materials and silazane materials can also be effectively used.

[0098] According to the necessary function, the end or intermediate site of the alkyl chain may have a hetero atom, an unsaturated bond group, a cyclic bond group, an aromatic functional group or other group. In these compounds, the alkyl group contained therein is hydrophobic. Accordingly, the surface of the object material to be treated can easily be converted from a hydrophilic property to a hydrophobic property. As a result, even in the case of polymer materials having poor affinity in the untreated state, a high level of affinity can be realized.

[0099] When a plurality of types of fine particles are used as a mixture, fine particles different from each other in average particle diameter and, further, some of or all of material and shape are properly selected and used while taking the functions of the plurality of types of fine particles into consideration as described above.

[0100] Regarding the plurality of types of fine particles different from each other in material, the use of two or more types of fine particles different from each other in refractive index is preferred. When these fine particles are mixed together, the refractive index of the fine particles may be regarded as an average value dependent upon the refractive index of each type of fine particles and the ratio of use of each type of fine particles. The regulation of the mixing ratio of the fine particles can realize detailed refractive index setting. In

this case, the control of the refractive index is easier than the case where a single type of fine particles is used, and, consequently, various refractive index designs are possible. For example, when two types of fine particles different from each other in refractive index are used, a relationship of the average particle diameter R1 of the first fine particles > the average particle diameter R2 of the second fine particles is preferably satisfied. Alternatively, in this case, the two types of fine particles may be identical to each other in particle diameter. In this case, the ratio between the first fine particles and the second fine particles can be freely selected. This facilitates the design of light diffusing properties. In order to render the particle diameter of the first fine particles and the particle diameter of the second fine particles identical to each other, the use of organic fine particles which can easily provide monodisperse particles is preferred. The lower the level of variation of the particle diameter, advantageously the lower the level of variation in anti-dazzling properties and internal scattering properties and the easier the optical property design of the anti-dazzling layer. Means for further improving monodispersibility include pneumatic classification and wet filtration classification by a filter.

[0101] Antistatic Agent (Electroconductive Agent)

[0102] The anti-dazzling layer according to the present invention may contain an antistatic agent (an electroconductive agent). Dust adhesion to the surface of the optical laminate can be effectively prevented by adding an electroconductive agent. Specific examples of electroconductive agents (antistatic agents) include cationic group-containing various cationic compounds such as quaternary ammonium salts, pyridinium salts, primary, secondary and tertiary amino groups, anionic group-containing anionic compounds such as sulfonic acid bases, sulfuric ester bases, phosphoric ester bases, and phosphonic acid bases, amphoteric compounds such as amino acid and aminosulfuric ester compounds, non-ionic compounds such as amino alcohol, glycerin and polyethylene glycol compounds, organometallic compounds such as alkoxides of tin and titanium, and metal chelate compounds such as their acetylacetonate salts. Further, compounds produced by increasing the molecular weight of the above compounds may also be mentioned. Further, polymerizable compounds, for example, monomers or oligomers, which contain a tertiary amino group, a quaternary ammonium group, or a metallic chelate moiety and are polymerizable upon exposure to ionizing radiations, or organometallic compounds such as functional group-containing coupling agents may also be used as the antistatic agent.

[0103] Further, electroconductive fine particles may be mentioned as the antistatic agent. Specific examples of electroconductive fine particles include fine particles of metal oxides. Such metal oxides include ZnO (refractive index 1.90; the numerical values within the parentheses being refractive index; the same shall apply hereinafter), CeO_2 (1.95), Sb_2O_3 (1.71), SnO_2 (1.997), indium tin oxide often abbreviated to "ITO" (1.95), In_2O_3 (2.00), Al_2O_3 (1.63), antimony-doped tin oxide (abbreviated to "ATO," 2.0), and aluminum-doped zinc oxide (abbreviated to "AZO," 2.0). The term "fine particles" refers to fine particles having a size of not more than 1 micrometer, that is, fine particles of submicron size, preferably fine particles having an average particle diameter of 0.1 nm to 0.1 μm .

[0104] Electroconductive polymers may be mentioned as the antistatic agent, and specific examples thereof include: aliphatic conjugated polyacetylenes, polyacene, polyazulene

or the like; aromatic conjugated poly(paraphenylenes) or the like; heterocyclic conjugated polypyrroles, polythiophenes, polyisocyanaphthenes or the like; heteroatom-containing conjugated polyanilines, polythienylenevinylene or the like; and mixture-type conjugated poly(phenylenevinylene)s. Additional examples of electroconductive polymers include double-chain conjugated systems which are conjugated systems having a plurality of conjugated chains in the molecule thereof, and electroconductive composites which are polymers prepared by grafting or block-copolymerizing the above conjugated polymer chain onto a saturated polymer, and their electroconductive polymer derivatives. Among others, the use of organic antistatic agents such as polypyrrole, polythiophene, and polyaniline is more preferred. The use of the organic antistatic agent can realize the development of excellent antistatic properties and, at the same time, can enhance the total light transmittance of the optical laminate, and can lower the haze value. Further, with a view to improving the electroconductivity and improving the antistatic properties, anions of an organic sulfonic acid, iron chloride or the like may also be added as a dopant (an electron donating agent). Based on dopant addition effect, polythiophene has a high level of transparency and a high level of antistatic properties and thus is particularly preferred. Oligothiophene is also suitable as the polythiophene. The above derivatives are not particularly limited, and examples thereof include alkyl substitutes of polyphenylacetylene and polydiacetylene.

[0105] Resin

[0106] The anti-dazzling layer according to the present invention may be formed from a (curing-type) resin. The curing-type resin is preferably transparent, and specific examples thereof are classified into three groups, that is, ionizing radiation curing resins which are curable upon exposure to ultraviolet light or electron beams, mixtures of ionizing radiation curing resins with solvent drying resins (resins which can be brought to a film by merely removing a solvent by drying for regulating the solid content in the coating, for example, thermoplastic resins), or heat curing resins. Preferred are ionizing radiation curing resins. In a preferred embodiment of the present invention, the resin comprises at least an ionizing radiation curing resin and a heat curing resin.

[0107] Specific examples of ionizing radiation curing resins include compounds containing a radical polymerizable functional group such as an (meth)acrylate group, for example, (meth)acrylate oligomers, prepolymers, or monomers. Specific examples thereof include oligomers or prepolymers of relatively low-molecular weight polyester resins, polyether resins, acrylic resins, epoxy resins, urethane resins, alkyd resins, spiroacetal resins, polybutadiene resins, and polythiol polyene resins and (meth)acrylic esters of polyfunctional compounds such as polyhydric alcohols. Specific examples of monomers include ethyl (meth)acrylate, ethylhexyl (meth)acrylate, trimethylolpropane tri(meth)acrylate, hexanediol (meth)acrylate, tripropylene glycol di(meth)acrylate, diethylene glycol di(meth)acrylate, pentaerythritol tri(meth)acrylate, dipentaerythritol hexa(meth)acrylate, 1,6-hexanediol di(meth)acrylate, and neopentyl glycol di(meth)acrylate. The term "(meth)acrylate" means acrylate or methacrylate.

[0108] Examples of compounds other than the (meth)acrylate compound include monofunctional or polyfunctional monomers such as styrene, methylstyrene, and N-vinylpyrrolidone, or cation polymerizable functional group-containing compounds for example, oligomers and prepolymers of

bisphenol-type epoxy compounds, novolak-type epoxy compounds, aromatic vinyl ethers, and aliphatic vinyl ethers.

[0109] When ionizing radiation curing resins are used as an ultraviolet curing resin, preferably, a photopolymerization initiator is used. Specific examples of photopolymerization initiators include acetophenones, benzophenones, benzoin, propiophenones, benzyls, acylphosphine oxides, Michler's benzoyl benzoate, α -amyloxime ester, tetramethyl thiuram monosulfide, and thioxanthenes. Preferably, photosensitizers are mixed in the system. Specific examples of photosensitizers include n-butylamine, triethylamine, and poly-n-butylphosphine.

[0110] The solvent drying-type resin used as a mixture with the ionizing radiation curing resin is mainly a thermoplastic resin. Commonly exemplified thermoplastic resins are usable. Coating defects of the coated face can be effectively prevented by adding the solvent drying-type resin.

[0111] In a preferred embodiment of the present invention, when the light transparent base material is formed of a cellulosic resin such as triacetylcellulose "TAC," specific examples of preferred thermoplastic resins include cellulosic resins, for example, nitrocellulose, acetylcellulose, cellulose acetate propionate, and ethylhydroxyethylcellulose. When the cellulosic resin is used, the adhesion between the light transparent base material and the antistatic layer (if any) and transparency can be improved.

[0112] Further, in the present invention, in addition to the above-described resins, vinyl resins such as vinyl acetate and its copolymers, vinyl chloride and its copolymers, and vinylidene chloride and its copolymers, acetal resins such as polyvinylformal and polyvinylbutyral, acrylic resins such as acrylic resin and its copolymers and methacrylic resin and its copolymers, polystyrene resins, polyamide resins, and polycarbonate resins may be mentioned.

[0113] Specific examples of heat curing resin include phenolic resins, urea resins, diallyl phthalate resins, melanin resins, guanamine resins, unsaturated polyester resins, a polyurethane resins, epoxy resins, aminoalkyd resins, melamine-urea cocondensed resins, silicone resins, and polysiloxane resins. When the heat curing resin is used, if necessary, for example, curing agents such as crosslinking agents and polymerization initiators, polymerization accelerators, solvents, and viscosity modifiers may be further added.

[0114] Leveling Agent

[0115] Fluoro- or silicone-type or other leveling agents may be added to the composition for an anti-dazzling layer according to the present invention. The composition for an anti-dazzling layer to which the leveling agent has been added, advantageously has contamination preventive properties and scratch resistance. Preferably, the leveling agent is utilized in film-shaped light transparent base materials (for example, triacetylcellulose) which should be resistant to heat.

[0116] Method for Anti-Dazzling Layer Formation

[0117] The anti-dazzling layer may be formed by mixing fine particles or aggregation-type fine particles (preferably first fine particles and second fine particles, or first fine particles, second fine particles and third fine particles) and the resin in proper solvents, for example, toluene, xylene, cyclohexanone, methyl acetate, ethyl acetate, butyl acetate, propyl acetate, MEK (methyl ethyl ketone), and MIBK (methyl isobutyl ketone) to prepare a composition for an anti-dazzling layer or a composition for a substrate concavoconvex layer, and then coating the composition onto a light transparent base material.

[0118] Proper solvents include: alcohols such as methanol, ethanol, isopropyl alcohol, butanol, isobutyl alcohol, methyl glycol, methyl glycol acetate, methyl cellosolve, ethyl cellosolve, or butyl cellosolve; ketones such as acetone, methyl ethyl ketone, methyl isobutyl ketone, cyclohexanone, or diacetone alcohol; esters such as methyl formate, methyl acetate, ethyl acetate, ethyl lactate, or butyl acetate; nitrogen-containing compounds such as nitromethane, N-methylpyrrolidone, or N,N-dimethylformamide; ethers such as diisopropyl ether, tetrahydrofuran, dioxane, or dioxolane; halogenated hydrocarbons such as methylene chloride, chloroform, trichloroethane, or tetrachloroethane; other solvents such as dimethyl sulfoxide or propylene carbonate; or mixtures thereof. More preferred solvents include methyl acetate, ethyl acetate, butyl acetate, methyl ethyl ketone, methyl isobutyl ketone, or cyclohexanone.

[0119] Methods usable for coating the composition for an anti-dazzling layer onto the light transparent base material include coating methods such as roll coating, Mayer bar coating, and gravure coating. Coating the composition for an anti-dazzling layer or the composition for a substrate concavoconvex layer is followed by drying and ultraviolet curing. Specific examples of ultraviolet light sources include light sources, for example, ultra-high-pressure mercury lamps, high-pressure mercury lamps, low-pressure mercury lamps, carbon arc lamps, black light fluorescent lamps, and metal halide lamps. Regarding the wavelength of the ultraviolet light, a wavelength range of 190 to 380 nm may be used. Specific examples of electron beam sources include various electron beam accelerators, for example, Cockcroft-Walton accelerators, van de Graaff accelerators, resonance transformer accelerators, insulated core transformer accelerators, linear accelerators, Dynamitron accelerators, and high-frequency accelerators. The resin is cured, and the fine particles in the resin are fixed to form a desired concavoconvex shape on the outermost surface of the anti-dazzling layer or the substrate concavoconvex layer.

[0120] 2) Anti-Dazzling Layer Formed Using Composition for Anti-Dazzling Layer, Free from Fine Particles and Containing Resin and the Like

[0121] In the present invention, the anti-dazzling layer may be formed by mixing at least one polymer with at least one curable resin precursor in a proper solvent to prepare a composition for an anti-dazzling layer and applying the composition onto a light transparent base material. This anti-dazzling layer may be the same as described above in the column of 1) Anti-dazzling layer formed using composition for anti-dazzling layer, comprising resin and fine particles, except that the anti-dazzling agent is not used.

[0122] Polymer

[0123] The polymer may be a plurality of polymers which can be phase separated by a spinodal decomposition, for example, a cellulose derivative and a styrenic resin, an (meth) acrylic resin, an alicyclic olefinic resin, a polycarbonate resin, a polyester resin or the like, or a combination thereof. The curable resin precursor may be compatible with at least one polymer in the plurality of polymers. At least one of the plurality of polymers may have a functional group involved in a curing reaction of the curable resin precursor, for example, a polymerizable group such as an (meth)acryloyl group. In general, a thermoplastic resin is used as the polymer component.

[0124] Specific examples of thermoplastic resins include styrenic resins, (meth)acrylic resins, organic acid vinyl ester

resins, vinyl ether resins, halogen-containing resins, olefinic resins (including alicyclic olefinic resins), polycarbonate resins, polyester resins, polyamide resins, thermoplastic polyurethane resins, polysulfone resins (for example, polyether-sulfone and polysulfone), polyphenylene ether resins (for example, polymers of 2,6-xylenol), cellulose derivatives (for example, cellulose esters, cellulose carbamates, and cellulose ethers), silicone resins (for example, polydimethylsiloxane and polymethylphenylsiloxane), and rubbers or elastomers (for example, diene rubbers such as polybutadiene and polyisoprene, styrene-butadiene copolymers, acrylonitrile-butadiene copolymers, acrylic rubbers, urethane rubbers, and silicone rubbers). They may be used either solely or in a combination of two or more.

[0125] Specific examples of styrenic resins include homopolymers or copolymers of styrenic monomers (for example, polystyrenes, styrene- α -methylstyrene copolymers, and styrene-vinyltoluene copolymers) and copolymers of styrenic monomers with other polymerizable monomers (for example, (meth)acrylic monomers, maleic anhydride, maleimide monomers, or dienes). Styrenic copolymers include, for example, styrene-acrylonitrile copolymers (AS resins), copolymers of styrene with (meth)acrylic monomers (for example, styrene-methyl methacrylate copolymers, styrene-methyl methacrylate-(meth)acrylic ester copolymers, or styrene-methyl methacrylate-(meth)acrylic acid copolymers), and styrene-maleic anhydride copolymers. Preferred styrenic resins include copolymers of polystyrene or styrene with (meth)acrylic monomers (for example, copolymers composed mainly of styrene and methyl methacrylate, for example, styrene-methyl methacrylate copolymers), AS resins, and styrene-butadiene copolymers.

[0126] For example, homopolymers or copolymers of (meth)acrylic monomers and copolymers of (meth)acrylic monomers with copolymerizable monomers may be mentioned as the (meth)acrylic resin. Specific examples of (meth)acrylic monomers include (meth)acrylic acid; C_{1-10} alkyl (meth)acrylates such as methyl (meth)acrylate, ethyl (meth)acrylate, butyl (meth)acrylate, t-butyl (meth)acrylate, isobutyl (meth)acrylate, hexyl (meth)acrylate, octyl (meth)acrylate, and 2-ethylhexyl (meth)acrylate; aryl (meth)acrylates such as phenyl (meth)acrylate; hydroxyalkyl (meth)acrylate such as hydroxyethyl (meth)acrylate and hydroxypropyl (meth)acrylate; glycidyl (meth)acrylate; N,N-dialkylaminoalkyl (meth)acrylate; (meth)acrylonitrile; and (meth)acrylates containing an alicyclic hydrocarbon group such as tricyclodecane. Specific examples of copolymerizable monomers include the above styrenic monomers, vinyl ester monomers, maleic anhydride, maleic acid, and fumaric acid. These monomers may be used either solely or in a combination of two or more.

[0127] Specific examples of (meth)acrylic resins include poly(meth)acrylic esters such as polymethyl methacrylate, methyl methacrylate-(meth)acrylic acid copolymers, methyl methacrylate-(meth)acrylic ester copolymers, methyl methacrylate-acrylic ester-(meth)acrylic acid copolymers, and (meth)acrylic ester-styrene copolymers (for example, MS resins). Specific examples of preferred (meth)acrylic resins include poly- C_{1-6} alkyl (meth)acrylates such as polymethyl (meth)acrylate. In particular, methyl methacrylate resins composed mainly of methyl methacrylate (approximately 50 to 100% by weight, preferably 70 to 100% by weight) may be mentioned.

[0128] Specific examples of organic acid vinyl ester resins include homopolymers or copolymers of vinyl ester monomers (for example, polyvinyl acetate and polyvinyl propionate), copolymers of vinyl ester monomers with copolymerizable monomers (for example, ethylene-vinyl acetate copolymers, vinyl acetate-vinyl chloride copolymers, and vinyl acetate-(meth)acrylic ester copolymers), or their derivatives. Specific examples of vinyl ester resin derivatives include polyvinyl alcohol, ethylene-vinyl alcohol copolymers, and polyvinylacetal resins.

[0129] Specific examples of vinyl ether resins include homopolymers or copolymers of vinyl C_{1-10} alkyl ethers such as vinyl methyl ether, vinyl ethyl ether, vinyl propyl ether, or vinyl *t*-butyl ether, and copolymers of vinyl C_{1-10} alkyl ethers with copolymerizable monomers (for example, vinyl alkyl ether-maleic anhydride copolymers). Specific examples of halogen-containing resins include polyvinyl chloride, polyfluorinated vinylidenes, vinyl chloride-vinyl acetate copolymers, vinyl chloride-(meth)acrylic ester copolymers, and vinylidene chloride-(meth)acrylic ester copolymers.

[0130] Specific examples of olefinic resins include homopolymers of olefins such as polyethylene and polypropylene, and copolymers such as ethylene-vinyl acetate copolymers, ethylene-vinyl alcohol copolymers, ethylene-(meth)acrylic acid copolymers, and ethylene-(meth)acrylic ester copolymers. Specific examples of alicyclic olefinic resins include homopolymers or copolymers of cyclic olefins (for example, norbornene and dicyclopentadiene) (for example, polymers containing an alicyclic hydrocarbon group such as tricyclodecane which is sterically rigid), and copolymers of the above cyclic olefins with copolymerizable monomers (for example, ethylene-norbornene copolymers and propylene-norbornene copolymers). Specific examples of alicyclic olefinic resins include those which are available, for example, under the tradenames "ARTON" and "ZEONEX."

[0131] Specific examples of polycarbonate resins include aromatic polycarbonates based on bisphenols (for example, bisphenol A), and aliphatic polycarbonates such as diethylene glycol bisallyl carbonates. Specific examples of polyester resins include aromatic polyesters using aromatic dicarboxylic acids such as terephthalic acid, for example, homopolyesters, for example, poly- C_{2-4} -alkylene terephthalates and poly- C_{2-4} -alkylene naphthalates including polyethylene terephthalate and polybutylene terephthalate, and copolyesters comprising as a main component (for example, not less than 50% by weight) C_{2-4} alkylene arylate units (C_{2-4} alkylene terephthalate and/or C_{2-4} alkylene naphthalate units). Specific examples of copolyesters include copolyesters in which, in the constituent units of poly- C_{2-4} -alkylene arylate, a part of C_{2-4} alkylene glycol has been replaced, for example, with a polyoxy- C_{2-4} -alkylene glycol, a C_{5-10} alkylene glycol, an alicyclic diol (for example, cyclohexanedimethanol or hydrogenated bisphenol A), an aromatic ring-containing diol (for example, 9,9-bis(4-(2-hydroxyethoxy)phenyl)fluorene having a fluorenone side chain, bisphenol A, or a bisphenol A-alkylene oxide adduct), and copolyesters in which a part of aromatic dicarboxylic acid has been replaced, for example, with an asymmetric aromatic dicarboxylic acid such as phthalic acid or isophthalic acid, or an aliphatic C_{5-12} dicarboxylic acid such as adipic acid. Specific examples of polyester resins include polyarylate resins, aliphatic polyesters using aliphatic dicarboxylic acids such as adipic acid, and homopolymers or copolymers of lactones such as δ -caprolac-

tone. Preferred polyester resins are generally noncrystalline polyester resins such as noncrystalline copolyesters (for example, C_{2-4} alkylene arylate copolyesters).

[0132] Specific examples of polyamide resins include aliphatic polyamides such as nylon 46, nylon 6, nylon 66, nylon 610, nylon 612, nylon 11, and nylon 12, and polyamides produced from dicarboxylic acids (for example, terephthalic acid, isophthalic acid, or adipic acid) and diamines (for example, hexamethylenediamine or metaxylenediamine). Specific examples of polyamide resins include homopolymers or copolymers of lactams such as δ -caprolactam. The polyamide resins may be either homopolyamides or copolyamides.

[0133] Specific examples of cellulose esters among the cellulose derivatives include, for example, aliphatic organic acid esters, for example, cellulose acetates such as cellulose diacetate and cellulose triacetate; and C_{1-5} organic acid esters such as cellulose propionate, cellulose butyrate, cellulose acetate propionate, and cellulose acetate butyrate. Further examples thereof include aromatic organic acid esters (C_{7-12} aromatic carboxylic esters such as cellulose phthalate and cellulose benzoate) and inorganic acid esters, (for example, cellulose phosphate and cellulose sulphate). Mixed acid esters such as acetic acid-nitric acid cellulose ester may also be used. Specific examples of cellulose derivatives include cellulose carbamates (for example, cellulose phenylcarbamate) and further include cellulose ethers, for example, cyanoethylcellulose; hydroxy- C_{2-4} -alkylcelluloses such as hydroxyethylcellulose and hydroxypropylcellulose, C_{1-6} alkylcelluloses such as methylcellulose and ethylcellulose; and carboxymethylcellulose or its salt, benzylcellulose, and acetyl alkylcellulose.

[0134] Specific examples of preferred thermoplastic resins include styrenic resins, (meth)acrylic resins, vinyl acetate resins, vinyl ether resins, halogen-containing resins, alicyclic olefinic resins, polycarbonate resins, polyester resins, polyamide resins, cellulose derivatives, silicone resins, and rubbers or elastomers. Resins, which are usually noncrystalline and soluble in organic solvents (particularly common solvents which can dissolve a plurality of polymers or curable compounds). Particularly preferred are, for example, resins having a high level of moldability or film formability, transparency and weathering resistance, for example, styrenic resins, (meth)acrylic resins, alicyclic olefinic resins, polyester resins, and cellulose derivatives (for example, cellulose esters).

[0135] Polymers containing a functional group involved in a curing reaction (or a functional group reactive with a curable compound) are also usable as the polymer component. The polymers may contain a functional group in the main chain or side chain. The functional group may be introduced into the main chain, for example, by copolymerization or co-condensation. In general, however, the functional group is introduced into the side chain. Specific examples of such functional groups include condensable groups and reactive groups (for example, hydroxyl group, acid anhydride group, carboxyl group, amino group or imino group, epoxy group, glycidyl group, and isocyanate group), polymerizable groups (for example, C_{2-6} alkenyl groups such as vinyl, propenyl, isopropenyl, butenyl and allyl groups, C_{2-5} alkynyl groups such as ethynyl, propynyl, and butynyl groups, and Czar alkenylidene groups such as vinylidene groups), or groups containing these polymerizable groups (for example, (meth)acryloyl group). Among these functional groups, polymerizable groups are preferred.

[0136] The polymerizable group may be introduced into the side chain, for example, by reacting a thermoplastic resin containing a functional group such as a reactive group or a condensable group with a polymerizable compound containing a group reactive with the functional group.

[0137] Examples of such functional group-containing thermoplastic resins include thermoplastic resins containing a carboxyl group or its acid anhydride group (for example, (meth)acrylic resins, polyester resins, and polyamide resins), hydroxyl group-containing thermoplastic resins (for example, (meth)acrylic resins, polyurethane resins, cellulose derivatives, and polyamide resins), amino group-containing thermoplastic resins (for example, polyamide resins), epoxy group-containing thermoplastic resins (for example, epoxy group-containing (meth)acrylic resins and polyester resins). Resins comprising the above functional group introduced into thermoplastic resins such as styrenic resins, olefinic resins, or alicyclic olefinic resins by copolymerization or graft polymerization are also possible.

[0138] Regarding the polymerizable compound, thermoplastic resins containing a carboxyl or its acid anhydride group include polymerizable compounds containing epoxy, hydroxyl, amino, or isocyanate groups. Hydroxyl group-containing thermoplastic resins include polymerizable compounds containing carboxyl groups or acid anhydride groups thereof or isocyanate groups. Amino group-containing thermoplastic resins include polymerizable compounds containing carboxyl groups or acid anhydride groups thereof, epoxy groups, or isocyanate groups. Epoxy group-containing thermoplastic resins include polymerizable compounds containing carboxyl groups or acid anhydride groups thereof or amino groups.

[0139] Among the above polymerizable compounds, epoxy group-containing polymerizable compounds include, for example, epoxycyclo-C₅₋₈-alkenyl (meth)acrylates such as epoxycyclohexenyl (meth)acrylate, glycidyl (meth)acrylate, and allyl glycidyl ether. Hydroxyl group-containing compounds include, for example, hydroxy-C₁₋₄-alkyl (meth)acrylates such as hydroxypropyl (meth)acrylate, and C₂₋₆ alkylene glycol (meth)acrylates such as ethylene glycol mono (meth)acrylate. Amino group-containing polymerizable compounds include, for example, amino-C₁₋₄-alkyl (meth)acrylates such as aminoethyl (meth)acrylate, C₃₋₆ alkenylamines such as allylamine, and aminostyrenes such as 4-aminostyrene and diaminostyrene. Isocyanate group-containing polymerizable compounds include, for example, (poly)urethane (meth)acrylate and vinyl isocyanate. Polymerizable compounds containing carboxyl groups or acid anhydride groups thereof include, for example, unsaturated carboxylic acids or anhydrides thereof such as (meth)acrylic acid and maleic anhydride.

[0140] A combination of a thermoplastic resin containing a carboxyl group or its acid anhydride group with an epoxy group-containing compound, particularly a combination of an (meth)acrylic resin (for example, an (meth)acrylic acid-(meth)acrylic ester copolymer) with an epoxy group-containing (meth)acrylate (for example, epoxycycloalkenyl (meth)acrylate or glycidyl (meth)acrylate) may be mentioned as a representative example of the polymerizable compound. Specific examples thereof include polymers comprising a polymerizable unsaturated group introduced into a part of carboxyl groups in an (meth)acrylic resin, for example, an (meth)acrylic polymer produced by reacting a part of carboxyl groups in an (meth)acrylic acid-(meth)acrylic ester

copolymer with an epoxy group in 3,4-epoxycyclohexenylmethyl acrylate to introduce a photopolymerizable unsaturated group into the side chain (CYCLOMER P, manufactured by Daicel Chemical Industries, Ltd.).

[0141] The amount of the functional group (particularly polymerizable group) involved in a curing reaction with the thermoplastic resin introduced is approximately 0.001 to 10 moles, preferably 0.01 to 5 moles, more preferably 0.02 to 3 moles based on 1 kg of the thermoplastic resin.

[0142] These polymers may be used in a suitable combination. Specifically, the polymer may comprise a plurality of polymers. The plurality of polymers may be phase separated by liquid phase spinodal decomposition. The plurality of polymers may be incompatible with each other. When the plurality of polymers are used in combination, the combination or a first resin with a second resin is not particularly limited. For example, a plurality of polymers incompatible with each other at a temperature around a processing temperature, for example, two suitable polymers incompatible with each other may be used in combination. For example, when the first resin is a styrenic resin (for example, polystyrene or a styrene-acrylonitrile copolymer), examples of second resins usable herein include cellulose derivatives (for example, cellulose esters such as cellulose acetate propionate), (meth)acrylic resins (for example, polymethyl methacrylate), alicyclic olefinic resins (for example, polymers using norbornene as a monomer), polycarbonate resins, and polyester resins (for example, the above poly-C₂₋₄-alkylene arylate copolyesters). On the other hand, for example, when the first polymer is a cellulose derivative (for example, a cellulose ester such as cellulose acetate propionate), examples of second polymers usable herein include styrenic resins (for example, polystyrene or styrene-acrylonitrile copolymer), (meth)acrylic resins, alicyclic olefinic resins (for example, polymers using norbornene as a monomer), polycarbonate resins, and polyester resins (for example, the above poly-C₂₋₄-alkylene arylate copolyesters). In the combination of the plurality of resins, at least cellulose esters (for example, cellulose C₂₋₄ alkyl carboxylic esters such as cellulose diacetate, cellulose triacetate, cellulose acetate propionate, or cellulose acetate butyrate) may be used.

[0143] The phase separated structure produced by the spinodal decomposition is finally cured by the application of an actinic radiation (for example, ultraviolet light or electron beam), heat or the like to form a cured resin. By virtue of this, the scratch resistance can be imparted to the anti-dazzling layer, and the durability can be improved.

[0144] From the viewpoint of scratch resistance after curing, preferably, at least one polymer in the plurality of polymers, for example, one of mutually incompatible polymers (when the first and second resins are used in combination, particularly both the polymers) is a polymer having on its side chain a functional group reactive with a curable resin precursor.

[0145] The weight ratio between the first polymer and the second polymer may be selected, for example, from a range of first polymer/second polymer=approximately 1/99 to 99/1, preferably 5/95 to 95/5, more preferably 10/90 to 90/10 and is generally approximately 20/80 to 80/20, particularly 30/70 to 70/30.

[0146] Regarding the polymer for phase separated structure formation, in addition to the above two incompatible polymers, the above thermoplastic resins or other polymers may be incorporated.

[0147] The glass transition temperature of the polymer may be selected, for example, from a range of approximately -100°C. to 250°C. , preferably -50°C. to 230°C. , more preferably 0 to 200°C. (for example, approximately 50 to 180°C.). A glass transition temperature of 50°C. or above (for example, approximately 70 to 200°C.), preferably 100°C. or above (for example, approximately 100 to 170°C.), is advantageous from the viewpoint of the surface hardness. The weight average molecular weight of the polymer may be selected, for example, from a range of approximately not more than $1,000,000$, preferably $1,000$ to $500,000$.

[0148] Curable Resin Precursor

[0149] The curable resin precursor is a compound containing a functional group which can be reacted upon exposure to heat or an actinic radiation (for example, ultraviolet light or electron beams) or the like, and various curable compounds, which can be cured or crosslinked upon exposure to heat, an actinic radiation or the like to form a resin (particularly a cured or crosslinked resin), can be used. Examples of such resin precursors include heat curing compounds or resins [low-molecular weight compounds containing epoxy groups, polymerizable groups, isocyanate groups, alkoxysilyl groups, silanol groups or the like (for example, epoxy resins, unsaturated polyester resins, urethane resins, or silicone resins)], and photocuring compounds curable upon exposure to an actinic radiation (for example, ultraviolet light) (for example, ultraviolet light curing compounds such as photocuring monomers and oligomers). The photocuring compound may be, for example, an EB (electron beam) curing compound. Photocuring compounds such as photocuring monomers, oligomers, photocuring resins which may have a low-molecular weight, are sometimes referred to simply as "photocuring resin."

[0150] Photocuring compounds include, for example, monomers and oligomers (or resins, particularly low-molecular weight resins). Monomers include, for example, monofunctional monomers [for example, (meth)acrylic monomers such as (meth)acrylic esters, vinyl monomers such as vinylpyrrolidone, and crosslinked ring-type hydrocarbon group-containing (meth)acrylates such as isobornyl (meth)acrylate or adamantyl (meth)acrylate], polyfunctional monomers containing at least two polymerizable unsaturated bonds [for example, alkylene glycol di(meth)acrylates such as ethylene glycol di(meth)acrylate, propylene glycol di(meth)acrylate, butanediol di(meth)acrylate, neopentyl glycol di(meth)acrylate, and hexanediol di(meth)acrylate; (poly)oxyalkylene glycol di(meth)acrylates such as diethylene glycol di(meth)acrylate, dipropylene glycol di(meth)acrylate, and polyoxytetramethylene glycol di(meth)acrylate; crosslinked ring-type hydrocarbon group-containing di(meth)acrylates such as tricyclodecane dimethanol di(meth)acrylate and adamantane di(meth)acrylate; and polyfunctional monomers containing about three to six polymerizable unsaturated bonds such as trimethylolpropane tri(meth)acrylate, trimethylolethane tri(meth)acrylate, pentaerythritol tri(meth)acrylate, pentaerythritol tetra(meth)acrylate, and dipentaerythritol penta(meth)acrylate].

[0151] Oligomers or resins include (meth)acrylate or epoxy (meth)acrylate of bisphenol A-alkylene oxide adducts (for example, bisphenol A-type epoxy (meth)acrylate and novolak-type epoxy (meth)acrylate), polyester (meth)acrylates (for example, aliphatic polyester-type (meth)acrylate and aromatic polyester-type (meth)acrylate), (poly)urethane (meth)acrylates (for example, polyester-type urethane (meth)

acrylate, polyether-type urethane (meth)acrylate), and silicone (meth)acrylate. These photocuring compounds are usable either solely or in a combination of two or more.

[0152] Preferred curable resin precursors include photocuring compounds curable in a short time, for example, ultraviolet light curing compounds (for example, monomers, oligomers and resins which may have a low-molecular weight), and EB curing compounds. Resin precursors which are particularly advantageous from the practical viewpoint are ultraviolet light curing resins. From the viewpoint of improving resistance such as scratch resistance, preferably, the photocuring resin is a compound having in its molecule two or more (preferably approximately 2 to 6 , more preferably 2 to 4) polymerizable unsaturated bonds. The molecular weight of the curable resin precursor is approximately not more than 5000 , preferably not more than 2000 , more preferably not more than 1000 , from the viewpoint of compatibility with the polymer.

[0153] The curable resin precursor may contain a curing agent depending upon the type of the curable resin precursor. For example, in the case of heat curing resins, curing agents such as amines or polycarboxylic acids may be contained, and, in the case of photocuring resins, photopolymerization initiators may be contained. Examples of photopolymerization initiators include commonly used components, for example, acetophenones or propiophenones, benzyls, benzoin, benzophenones, thioxanthenes, and acylphosphine oxides. The content of the curing agent such as a photocuring agent is approximately 0.1 to 20 parts by weight, preferably 0.5 to 10 parts by weight, more preferably 1 to 8 parts by weight (particularly 1 to 5 parts by weight), based on 100 parts by weight of the curable resin precursor and may be approximately 3 to 8 parts by weight.

[0154] The curable resin precursor may contain a curing accelerator. For example, the photocuring resin may contain photocuring accelerators, for example, tertiary amines (for example, dialkylaminobenzoic esters) and phosphine photopolymerization accelerators.

[0155] Specific Combination of Polymer with Curable Resin Precursor

[0156] At least two components in at least one polymer and at least one curable resin precursor may be used in a combination of materials which are mutually phase separated at a temperature around the processing temperature. Examples of such combinations include (a) a combination of a plurality of polymers which are mutually incompatible and phase separated, (b) a combination of a polymer and a curable resin precursor which are mutually incompatible and phase separated, and (c) a combination of a plurality of curable resin precursors which are mutually incompatible and phase separated. Among these combinations, (a) a combination of a plurality of polymers and (b) a combination of a polymer with a curable resin precursor are generally preferred, and particularly (a) a combination of a plurality of polymers is preferred. When the compatibility of both the materials to be phase separated is low, both the materials are effectively phase separated in the course of drying for evaporating the solvent and the function as an anti-dazzling layer can be improved.

[0157] The thermoplastic resin and the curable resin precursor (or curing resin) are generally incompatible with each other. When the polymer and the curable resin precursor are incompatible with each other and phase separated, a plurality of polymers may be used as the polymer. When a plurality of polymers are used, meeting the requirement that at least one

polymer is incompatible with the resin precursor (or curing resin) suffices for contemplated results, and the other polymer (s) may be compatible with the resin precursor.

[0158] A combination of two mutually incompatible thermoplastic resins with a curing compound (particularly a monomer or oligomer containing a plurality of curable functional groups) may be adopted. From the viewpoint of scratch resistance after curing, one polymer (particularly both polymers) in the incompatible thermoplastic resins may be a thermoplastic resin containing a functional group involved in the curing reaction (a functional group involved in curing of the curable resin precursor).

[0159] When a combination of a plurality of mutually incompatible polymers is adopted for phase separation, the curable resin precursor to be used in combination with the plurality of mutually incompatible polymers is compatible with at least one polymer in the plurality of incompatible polymers at a temperature around the processing temperature. Specifically, for example, when the plurality of mutually incompatible polymers are constituted by the first resin and the second resin, the curable resin precursor may be one which is compatible with at least one of the first resin and the second resin, preferably is compatible with both the polymer components. When the curable resin precursor is compatible with both the polymer components, phase separation occurs into at least two phases, i.e., a mixture composed mainly of a first resin and a curable resin precursor and a mixture composed mainly of a second resin and a curable resin precursor.

[0160] When the compatibility of a plurality of selected polymers is low, the polymers are effectively phase separated from each other in the course of drying for evaporating the solvent and the function as an anti-dazzling layer is improved. The phase separability of the plurality of polymers can be simply determined by a method in which a homogeneous solution is prepared using a good solvent for both the components and the solvent is gradually evaporated to visually inspect whether or not the residual solid matter is opaque in the course of evaporation.

[0161] In general, the polymer and the cured or crosslinked resin produced by curing of the resin precursor are different from each other in refractive index. Further, the plurality of polymers (first and second resins) are also different from each other in refractive index. The difference in refractive index between the polymer and the cured or crosslinked resin, and the difference in refractive index between the plurality of polymers (first and second resins) may be, for example, approximately 0.001 to 0.2, preferably 0.05 to 0.15.

[0162] The weight ratio between the polymer and the curable resin precursor is not particularly limited and may be selected, for example, from a range of polymer/curable resin precursor=approximately 5/95 to 95/5, and, from the viewpoint of surface hardness, is preferably polymer/curable resin precursor=approximately 5/95 to 60/40, more preferably 10/90 to 50/50, particularly preferably 10/90 to 40/60.

[0163] Solvent

[0164] The solvent may be selected and used according to the type and solubility of the polymer and curable resin precursor. A solvent capable of homogeneously dissolving at least the solid matter (a plurality of polymers and curable resin precursor, a reaction initiator, and other additives) suffices for contemplated results and may be used in wet spinodal decomposition. Examples of such solvents include ketones (for example, acetone, methyl ethyl ketone, methyl isobutyl ketone, and cyclohexanone), ethers (for example,

dioxane and tetrahydrofuran), aliphatic hydrocarbons (for example, hexane), alicyclic hydrocarbons (for example, cyclohexane), aromatic hydrocarbons (for example, toluene and xylene), halogenated hydrocarbons (for example, dichloromethane and dichloroethane), esters (for example, methyl acetate, ethyl acetate and butyl acetate), water, alcohols (for example, ethanol, isopropanol, butanol, and cyclohexanol), cellosolves (for example, methylcellosolve and ethylcellosolve), cellosolve acetates, sulfoxides (for example, dimethylsulfoxide), and amides (for example, dimethylformamide and dimethylacetamide). A mixture solvents composed of two or more of these solvents may be used.

[0165] The concentration of the solute (polymer and curable resin precursor, reaction initiator, and other additives) in the composition for an anti-dazzling layer may be selected from such a range that causes phase separation and such a range that castability, coatability and the like are not deteriorated. The solute concentration is, for example, approximately 1 to 80% by weight, preferably 5 to 60% by weight, more preferably 15 to 40% by weight (particularly 20 to 40% by weight).

[0166] Penetrating Solvent

[0167] In a preferred embodiment of the present invention, in order to render the interface between the light transparent base material and the anti-dazzling layer absent, preferably, the anti-dazzling layer is formed using a composition for an anti-dazzling layer, which is penetrable into the light transparent base material. The details of the penetrating solvent may be the same as those described above in "1) Anti-dazzling-layer formed using composition for anti-dazzling layer comprising fine particles added to resin."

[0168] Method for Anti-Dazzling Layer Formation

[0169] The anti-dazzling layer may be formed using a composition for an anti-dazzling layer, comprising at least one polymer and at least one curable resin precursor. The use of a composition for an anti-dazzling layer prepared by mixing at least one polymer and at least one curable resin precursor with, if necessary, a penetrating solvent, and a suitable solvent is advantageous in that at least an anti-dazzling layer can be formed by forming a phase separated structure by spinodal decomposition from a liquid phase and curing the curable resin precursor.

[0170] The spinodal decomposition from the liquid phase can be carried out by evaporating the solvent. The combination of materials which can form a phase separated structure may be, for example, a combination of a plurality of polymers, a combination of a polymer and a curable resin precursor, or a combination of a plurality of curable resin precursors. In this method, an anti-dazzling layer may be formed by subjecting a composition comprising a thermoplastic resin, a photocuring compound (for example, a photopolymerizable monomer or oligomer), a photopolymerization initiator, and a solvent capable of dissolving the thermoplastic resin and photocuring compound (a common solvent) to spinodal decomposition to form a phase separated structure and exposing the product to light. Alternatively, the anti-dazzling layer may be formed by subjecting a composition comprising a thermoplastic resin, a resin incompatible with the thermoplastic resin and containing a photocurable group, a photocuring compound, a photopolymerization initiator, and a solvent capable of dissolving the resin and the photocuring compound to spinodal decomposition to form a phase separated structure, and applying light to the assembly. In these

methods, at least one anti-dazzling layer may be formed on a light transparent base material.

[0171] Specific Formation Method

[0172] The anti-dazzling layer may be formed by a process comprising the steps of: mixing at least one polymer and at least one curable resin precursor using a proper solvent to prepare a composition for an anti-dazzling layer, applying the composition for an anti-dazzling layer onto a light transparent base material and then subjecting the coating to spinodal decomposition involving the evaporation of the solvent to form a phase separated structure; and curing the curable resin precursor to form at least an anti-dazzling layer. The phase separation step generally comprises the step of coating or casting a mixed liquid containing a polymer, a curable resin precursor and a solvent (particularly a liquid composition such as a homogeneous solution) onto the surface of a light transparent base material and the step of evaporating the solvent from the coating layer or casting layer to form a phase separated structure having a regular or periodical average phase-to-phase distance. The anti-dazzling layer can be formed by curing the curable resin precursor.

[0173] In a preferred embodiment of the present invention, the mixed liquid may be a composition for an anti-dazzling layer, comprising a thermoplastic resin, a photocuring compound, a photopolymerization initiator, and a solvent capable of dissolving the thermoplastic resin and photocuring compound. The anti-dazzling layer is formed by applying light to photocurable components in the phase separated structure formed by the spinodal decomposition to cure the photocurable components. In another preferred embodiment of the present invention, the mixed liquid may be a composition for an anti-dazzling layer, comprising a plurality of mutually incompatible polymers, a photocuring compound, a photopolymerization initiator, and a solvent. In this case, the anti-dazzling layer is formed by applying light to photocurable components in the phase separated structure formed by the spinodal decomposition to cure the photocurable components.

[0174] The spinodal decomposition involving the evaporation of the solvent can impart regularity or periodicity to the average distance between domains in the phase separated structure. The phase separated structure formed by the spinodal decomposition can be immediately fixed by curing the curable resin precursor. The curable resin precursor can be cured, for example, by heating or light irradiation or a combination of these methods according to the type of the curable resin precursor. The heating temperature can be selected from a suitable temperature range, for example, from a range of approximately 50 to 150° C., so far as the phase separated structure is present, and may be selected from the same temperature range as in the phase separation step.

[0175] The anti-dazzling layer constituting a part of the optical laminate is formed by forming a phase separated structure in the anti-dazzling layer by spinodal decomposition (wet spinodal decomposition) from a liquid phase. Specifically, a composition for an anti-dazzling layer according to the present invention, comprising a polymer, a curable resin precursor, and a solvent is provided. The solvent is evaporated or removed from the composition for an anti-dazzling layer in its liquid phase (or a homogeneous solution or coating layer thereof) by drying or the like. In the course of drying or the like, an increase in concentration causes phase separation by spinodal decomposition to form a phase separated structure having a relatively regular phase-to-phase dis-

tance. More specifically, the wet spinodal decomposition is generally carried out by coating a composition for an anti-dazzling layer (preferably a homogeneous solution) comprising at least one polymer, at least one curable resin precursor, and a solvent onto a support and evaporating the solvent from the coating layer.

[0176] In the present invention, in the spinodal decomposition, as the phase separation proceeds, a co-continuous phase structure is formed. As the phase separation further proceeds, the continuous phase is rendered discontinuous by the surface tension or the phase per se to form a liquid droplet phase structure (a sea-island structure of spherical, truly spherical, disk-like, elliptical or other independent phases). Accordingly, depending upon the degree of the phase separation, a structure intermediate between a co-continuous phase structure and a liquid droplet phase structure (a phase structure in the course of transfer from the co-continuous phase to the liquid droplet phase) can also be formed. The phase separated structure of the anti-dazzling layer according to the present invention may be a sea-island structure (a liquid droplet phase structure or a phase structure in which one of the phases is independent or isolated), a co-continuous phase structure (or a network structure), or an intermediate structure in which a co-continuous phase structure and a liquid droplet phase structure exist together. By virtue of the phase separated structure, after the removal of the solvent by drying, fine concavoconvexes can be formed on the surface of the anti-dazzling layer.

[0177] In the phase separated structure, concavoconvexes are formed on the surface of the anti-dazzling layer, and, from the viewpoint of enhancing the surface hardness, a liquid droplet phase structure having at least island domains is advantageous. When the phase separated structure composed of the polymer and the precursor (or curable resin) is a sea-island structure, the polymer component may constitute a sea phase. From the viewpoint of the surface hardness, however, the polymer component preferably constitutes island domains. The formation of island domains leads to the formation of a concavoconvex shape having desired optical characteristics on the surface of the anti-dazzling layer after drying.

[0178] The average distance between domains in the phase separated structure is generally substantially regular or periodical and corresponds to the surface roughness S_m . The average distance between domains is, for example, not less than 50 μm and not more than 500 μm . Preferably, the lower limit of the average distance between domains is 60 μm , and the upper limit of the average distance between domains is about 400 μm . The average distance between domains in the phase separated structure may be regulated, for example, by properly selecting a combination of resins (particularly the selection of resins based on a solubility parameter). The distance between profile irregularities of the surface of the final optical laminate can be brought to a desired value by regulating the average distance between domains.

[0179] Except for the above matter, the anti-dazzling layer may be the same as those described above in "1) Anti-dazzling layer formed using composition for anti-dazzling layer-comprising fine particles added to resin."

[0180] 2. Surface Modifying Layer

[0181] In the present invention, in order to form an anti-dazzling layer, a substrate concavoconvex layer may be formed on a base material followed by the formation of a surface modifying layer on the substrate concavoconvex

layer. The surface modifying layer consists of only the resin material described above in connection with the anti-dazzling layer, or a composition comprising the resin material and a surface modifying agent added to the resin material. In the surface modifying layer, fine concavoconvexes present along the concavoconvex shape of the substrate concavoconvex layer on the scale of one-tenth or less of the concavo-convex scale (profile peak height of concavoconvexes and spacing between profile peaks) in the surface roughness in the concavoconvex shape of the substrate concavoconvex layer can be sealed for flattening to form smooth concavoconvexes with the concaves being substantially flat, or the spacing between profile peaks of the concavoconvexes and profile peak height, and the frequency (number) of the profile peaks can be regulated. The surface modifying layer is formed for surface modification purposes, for example, for imparting antistatic properties, refractive index regulation, hardness enhancement, and contamination preventive properties.

[0182] The thickness (on a cured state bases) of the surface modifying layer is not less than 0.6 μm and not more than 20 μm . Preferably, the lower limit of the thickness of the surface modifying layer is 3 μm , and the upper limit of the thickness of the surface modifying layer is 15 μm .

[0183] Surface Modifying Agent

[0184] One material or a mixture of two or more materials selected from the group consisting of antistatic agents, refractive index regulating agents, contamination preventive agents, water repellants, oil repellents, fingerprint adhesion preventive agents, hardness enhancing agents, and hardness regulating agents (cushioning property imparting agents) may be mentioned as the surface modifying agent.

[0185] Antistatic Agent (Electroconductive Agent)

[0186] The antistatic agent may be the same as described above in connection with the anti-dazzling layer. In a preferred embodiment of the present invention, the amount of the antistatic agent added to the binder resin (except for the solvent) is preferably 5 to 250% by mass. The regulation or the addition amount of the antistatic agent to the above-defined range is preferred from the viewpoints of maintaining the transparency as the optical laminate and imparting antistatic properties without adversely affecting glossy black feeling, anti-dazzling properties or other properties.

[0187] Refractive Index Regulating Agent

[0188] The refractive index regulating agent may be added to the surface modifying layer to regulate the optical properties of the optical laminate. Examples of such refractive index regulating agents include low-refractive index agents, medium-refractive index agents, and high-refractive index agents.

[0189] 1) Low-Refractive Index Agent

[0190] The refractive index of the surface modifying layer to which the low-refractive index agent has been added is lower than that of the anti-dazzling layer. In a preferred embodiment of the present invention, the refractive index of the surface modifying layer to which the low-refractive index agent has been added is less than 1.5, preferably not more than 1.45. When the refractive index falls within the above-defined range, advantageously, the physical properties such as hardness and scratch resistance of the surface modifying layer are not lowered.

[0191] Regarding the materials for the surface modifying layer, the mixing ratio between the resin component and the low-refractive index agent is preferably resin component/low-refractive index agent=approximately 30/70 to 95/5.

[0192] Preferred low-refractive index agents include low-refractive index inorganic ultrafine particles such as silica and magnesium fluoride (all types of fine particles such as porous and hollow fine particles), and fluororesins which are low-refractive index resins. Polymerizable compounds containing a fluorine atom at least in their molecule, or polymers thereof are usable as the fluororesin. The polymerizable compound is not particularly limited. However, for example, those containing a curing reactive group such as a functional group curable by an ionizing radiation or a heat curable polar group are preferred. Further, compounds simultaneously having these reactive groups are also possible. Unlike the polymerizable compounds, the polymer does not have the above reactive groups at all.

[0193] Ethylenically unsaturated bond-containing fluorine-containing monomers are extensively usable as the polymerizable compound having an ionizing radiation curing group. More specific examples thereof include fluoroolefins (for example, fluoroethylene, vinylidene fluoride, tetrafluoroethylene, hexafluoropropylene, perfluorobutadiene, and perfluoro-2,2-dimethyl-1,3-dioxol). Specific examples of (meth)acryloyloxy group-containing compounds include (meth)acrylate compounds having a fluorine atom in their molecule such as 2,2,2-trifluoroethyl (meth)acrylate, 2,2,3,3,3-pentafluoropropyl (meth)acrylate, 2-(perfluorobutyl)ethyl (meth)acrylate, 2-(perfluorohexyl)ethyl (meth)acrylate, 2-(perfluorooctyl)ethyl (meth)acrylate, 2-(perfluorodecyl)ethyl (meth)acrylate, methyl α -trifluoromethacrylate, and ethyl α -trifluoromethacrylate, and fluorine-containing polyfunctional (meth)acrylic ester compounds containing a fluoroalkyl, fluorocycloalkyl, or fluoroalkylene group which contains at least three fluorine atoms and has 1 to 14 carbon atoms and at least two (meth)acryloyloxy groups in their molecule.

[0194] Preferred heat curing polar groups include, for example, hydrogen bond forming groups such as hydroxyl, carboxyl, amino, and epoxy groups. These groups are excellent in adhesion to the coating film, as well as in affinity for inorganic ultrafine particles such as silica. Heat curing polar group-containing polymerizable compounds include, for example, 4-fluoroethylene-perfluoroalkyl vinyl ether copolymers; fluoroethylene-hydrocarbon-type vinyl ether copolymers; and fluorine modification products of resins such as epoxy resins, polyurethane resins, cellulose resins, phenolic resins, and polyimide resins.

[0195] Examples of polymerizable compounds containing both an ionizing radiation curing group and a heat curing polar group include partially and fully fluorinated alkyl, alkenyl, and aryl esters of acrylic or methacrylic acid, fully or partially fluorinated vinyl ethers, fully or partially fluorinated vinyl esters, and fully or partially fluorinated vinyl ketones.

[0196] Specific examples of fluoropolymers include polymers of a monomer or monomer mixture containing at least one of fluorine-containing (meth)acrylate compounds of the above ionizing radiation curing group-containing polymerizable compounds; copolymers of at least one of the above fluorine-containing (meth)acrylate compounds with (meth)acrylate compounds not containing a fluorine atom in their molecule, for example, methyl (meth)acrylate, ethyl (meth)acrylate, propyl (meth)acrylate, butyl (meth)acrylate, and 2-ethylhexyl (meth)acrylate; and homopolymers or copolymers of fluorine-containing monomers such as fluoroethylene, vinylidene fluoride, trifluoroethylene, chlorotrifluoroethylene, 3,3,3-trifluoropropylene, 1,1,2-trichloro-3,3,3-trifluoropropylene, and hexafluoropropylene.

[0197] Silicone-containing vinylidene fluoride copolymers which are copolymers comprising a silicone component incorporated into the above copolymers may also be used. Silicone components include (poly)dimethylsiloxanes, (poly)diethylsiloxanes, (poly)diphenylsiloxanes, (poly)methylphenylsiloxanes, alkyl-modified (poly)dimethylsiloxanes, azo group-containing (poly)dimethylsiloxanes, dimethyl silicones, phenylmethyl silicones, alkyl/aralkyl-modified silicones, fluorosilicones, polyether-modified silicones, fatty acid ester-modified silicones, methyl hydrogen silicones, silanol group-containing silicones, alkoxy group-containing silicones, phenol group-containing silicones, methacryl-modified silicones, acryl-modified silicones, amino-modified silicones, carboxylic acid-modified silicones, carbinol-modified silicones, epoxy-modified silicones, mercapto-modified silicones, fluorine-modified silicones, and polyether-modified silicones. Among others, those having a dimethylsiloxane structure are preferred.

[0198] Nonpolymers or polymers of the following compounds are also usable as the fluoro-resin. Specific examples thereof. Include compounds produced by reacting a fluorine-containing compound containing at least one isocyanate group in the molecule thereof with a compound containing in its molecule at least one functional group reactive with the isocyanate group, for example, an amino group, a hydroxyl group, or a carboxyl group; and compounds produced by reacting a fluorine-containing polyol such as a fluorine-containing polyether polyol, a fluorine-containing alkyl polyol, a fluorine-containing polyester polyol, or a fluorine-containing ϵ -caprolactone-modified polyol with an isocyanate group-containing compound.

[0199] Further, the above fluoroene atom-containing polymerizable compound and polymer may be used as a mixture with each resin component as described above in connection with the anti-dazzling layer. Furthermore, curing agents for curing reactive groups and the like and various additives and solvents for improving coatability or imparting contamination preventive properties may be properly used.

[0200] In a preferred embodiment of the present invention, the utilization of "void-containing fine particles" as a low-refractive index agent is preferred. "Void-containing fine particles" can lower the refractive index while maintaining the layer strength of the surface modifying layer. In the present invention, the term "void-containing fine particle" refers to a fine particle which has a structure comprising air filled into the inside of the fine particle and/or an air-containing porous structure and has such a property that the refractive index is lowered in reverse proportion to the proportion of air which occupies the fine particle as compared with the refractive index of the original fine particle. Further, such a fine particle which can form a nanoporous structure in at least a part of the inside and/or surface of the coating film by utilizing the form, structure, aggregated state, and dispersed state of the fine particle within the coating film, is also embraced in the present invention.

[0201] Specific examples of preferred void-containing inorganic fine particles are silica fine particles prepared by a technique disclosed in Japanese Patent Laid-Open No. 233611/2001. Other examples thereof include silica fine particles produced by a process described, for example, in Japanese Patent Laid-Open No. 133105/1995, No. 79616/2002, and No. 106714/2006. The void-containing silica fine particles can easily be produced. Further, the hardness of the void-containing fine particles is high. Therefore, when a surface

modifying layer is formed by using a mixture of the void-containing silica fine particles with a binder, the layer has improved strength and, at the same time, the refractive index can be regulated to a range of approximately 1.20 to 1.45. Hollow polymer fine particles produced by using a technique disclosed in Japanese Patent Laid-Open No. 80503/2002 are a specific example of preferred void-containing organic fine particles.

[0202] Fine particles which can form a nanoporous structure in at least a part of the inside and/or surface of the coating film include, in addition to the above silica fine particles, sustained release materials, which have been produced for increasing the specific surface area and adsorb various chemical substances on a packing column and the porous part of the surface, porous fine particles used for catalyst fixation purposes, or dispersions or aggregates of hollow fine particles to be incorporated in heat insulating materials or low-dielectric materials. Specific examples of such fine particles include commercially available products, for example, aggregates of porous silica fine particles selected from tradename Nipsil and tradename Nipgel manufactured by Nippon Silica Industrial Co., Ltd. and colloidal silica UP series (tradename), manufactured by Nissan Chemical Industries Ltd., having such a structure that silica fine particles have been connected to one another in a chain form, and fine particles in a preferred particle diameter range specified in the present invention may be selected from the above fine particles.

[0203] The average particle diameter of the "void-containing fine particles" is not less than 5 nm and not more than 300 nm. Preferably, the lower limit of the average particle diameter is 8 nm, and the upper limit of the average particle diameter is 100 nm. More preferably, the lower limit of the average particle diameter is 10 nm, and the upper limit of the average particle diameter is 80 nm. When the average diameter of the fine particles is in the above-defined range, excellent transparency can be imparted to the surface modifying layer.

[0204] 2) High-Refractive Agent/Medium-Refractive Index Agent

[0205] The high-refractive index agent and the medium-refractive index agent may be added to the surface modifying layer to further improve antireflective properties. The refractive index of the high-refractive index agent and medium-refractive index agent may be set in a range of 1.55 to 2.00. The medium-refractive index agent has a refractive index in the range of 1.55 to 1.80, and the refractive index of the high-refractive index agent is in the range of 1.65 to 2.00.

[0206] These refractive index agents include fine particles, and specific examples thereof (the numerical value within the parentheses being a refractive index) include zinc oxide (1.90), titania (2.3 to 2.7), ceria (1.95), tin-doped indium oxide (1.95), antimony-doped tin oxide (1.80), yttria (1.87), and zirconia (2.0).

[0207] Leveling Agent

[0208] A leveling agent may be added to the surface modifying layer. Preferred leveling agents include fluorine-type or silicone-type leveling agents. The surface modifying layer to which the leveling agent has been added can realize a good coated face, can impart slipperiness and contamination preventive properties to the coating film surface in coating or drying, and can impart scratch resistance.

[0209] Contamination Preventive Agent

[0210] A contamination preventive agent may be added to the surface modifying layer. The contamination preventive

agent is mainly used to prevent the contamination of the outermost surface of the optical laminate and can impart scratch resistance to the optical laminate. Specific examples of effective contamination preventive agents include additives which can develop water repellency, oil repellency, and fingerprint wiping-off properties. More specific examples of contamination preventive agents include fluorocompounds and silicon compounds or mixtures of these compounds. More specific examples thereof include fluoroalkyl group-containing silane coupling agents such as 2-perfluorooctylethyltriaminosilane. Among them, amino group-containing compounds are particularly preferred.

[0211] Resin

[0212] The surface modifying layer may comprise at least a surface modifying agent and a resin. When the surface modifying layer does not contain a surface modifying agent, the resin functions as a hardness enhancing agent or as a hardness regulating agent (a cushioning property imparting agent) or functions to seal fine concavoconvexes present in the substrate concavoconvex layer to render the concavoconvex surface smooth and gentle and to render the concaves substantially flat.

[0213] The resin is preferably transparent, and specific examples thereof are classified into three resins, that is, ionizing radiation curing resins which are curable upon exposure to ultraviolet light or electron beams, mixtures of ionizing radiation curing resins with solvent drying-type resins (resins which can be brought to a film by merely removing, by drying, a solvent for regulating the solid content in coating, for example, thermoplastic resin), and heat curing resins. Preferred are ionizing radiation curing resins.

[0214] Specific examples of ionizing radiation curing resins include compounds containing a radical polymerizable functional group such as an (meth)acrylate group, for example, (meth)acrylate-type oligomers, prepolymers, or monomers. Specific examples thereof include relatively low-molecular weight polyester resins, polyether resins, acrylic resins, epoxy resins, urethane resins, alkyd resins, spiroacetal resins, polybutadiene resins, polythiol polyene resins, and oligomers or prepolymers of (meth)acrylates of polyfunctional compounds such as polyhydric alcohols. Specific examples of monomers include ethyl (meth)acrylate, ethylhexyl (meth)acrylate, trimethylolpropane tri(meth)acrylate, hexanediol (meth)acrylate, tripropylene glycol di(meth)acrylate, diethylene glycol di(meth)acrylate, pentaerythritol tri(meth)acrylate, dipentaerythritol hexa(meth)acrylate, 1,6-hexanediol di(meth)acrylate, and neopentyl glycol di(meth)acrylate. The term "(meth)acrylate" as used herein means acrylate or methacrylate.

[0215] Examples of compounds other than (meth)acrylate compounds include monofunctional or polyfunctional monomers such as styrene, methyl styrene, and N-vinylpyrrolidone, or cation polymerizable functional group-containing compounds such as oligomers and prepolymers of bisphenol-type epoxy compounds, novolak-type epoxy compounds, aromatic vinyl ethers, and aliphatic vinyl ethers.

[0216] When the ionizing radiation curing resin is an ultraviolet curing resin, a photopolymerization initiator is preferably used. Specific examples of photopolymerization initiators include acetophenones, benzophenones, Michler's benzoyl benzoate, α -amylloxime ester, thioxanthenes, propiophenones, benzyls, benzoin, and acylphosphine oxides. Preferably, photosensitizers are mixed in the system. Specific examples of photosensitizers include n-butylamine, triethy-

lamine, and poly-n-butylphosphine. When ionizing radiation curing resins are used as an ultraviolet curing resin, a photopolymerization initiator or a photopolymerization accelerator may be added. In the case of a radical polymerizable unsaturated group-containing resin system, acetophenones, benzophenones, thioxanthenes, benzoin, benzoin methyl ether and the like are used as a photopolymerization initiator either solely or as a mixture of two or more. On the other hand, in the case of a cation polymerizable functional group-containing resin system, aromatic diazonium salts, aromatic sulfonium salts, aromatic idonium salts, metallocene compounds, benzoin sulfonic esters and the like may be used as a photopolymerization initiator either solely or as a mixture of two or more. The amount of the photopolymerization initiator added is 0.1 to 10 parts by weight based on 100 parts by weight of the ionizing radiation curing composition.

[0217] The solvent drying-type resin used as a mixture with the ionizing radiation curing resin is mainly a thermoplastic resin. Commonly exemplified thermoplastic resins are usable. The solvent drying-type resins when added, functions as a viscosity modifier to modify the viscosity of the composition and to effectively prevent coating film defects of coated face. Specific examples of preferred thermoplastic resins include styrenic resins, (meth)acrylic resins, vinyl acetate resins, vinyl ether resins, halogen-containing resins, alicyclic olefinic resins, polycarbonate resins, polyester resins, polyamide resins, cellulose derivatives, silicone resins, and rubbers or elastomers. The resin is generally noncrystalline and, at the same time, is soluble in an organic solvent (particularly a common solvent which can dissolve a plurality of polymers and curable compounds). Particularly preferred are resins having good moldability or film forming properties, transparency, and weathering resistance, for example, styrenic resins, (meth)acrylic resins, alicyclic olefinic resins, polyester resins, cellulose derivatives (for example, cellulose esters). In a preferred embodiment of the present invention, when the light transparent base material is formed of a cellulosic resin such as triacetylcellulose "TAC," specific examples of preferred thermoplastic resins include cellulosic resins, for example, nitrocellulose, acetylcellulose, cellulose acetate propionate, and ethyl hydroxyethylcellulose.

[0218] Specific examples of heat curing resin include phenolic resins, urea resins, diallyl phthalate resins, melanin resins, guanamine resins, unsaturated polyester resins, polyurethane resins, epoxy resins, aminoalkyd resins, melamine-urea cocondensed resins, silicone resins, and polysiloxane resins. When the heat curing resin is used, if necessary, for example, curing agents such as crosslinking agents and polymerization initiators, polymerization accelerators, solvents, and viscosity modifiers may be further added.

[0219] In a preferred embodiment of the present invention, the surface modifying layer may contain organic fine particles and inorganic fine particles (fluidity modifier C) for regulating the fluidity. Preferred fine particles are colloidal silica. An attempt to form a surface modifying layer to seal fine concavoconvexes for smoothing sometimes causes a significant lowering in anti-dazzling properties due to excessive smoothing. The formation of a film using the colloidal silica-containing composition can simultaneously realize both anti-dazzling properties and black color reproduction. The function by which such effect can be attained has not been fully elucidated yet but is believed to be as follows. The colloidal silica-containing composition, when the fluidity is regulated, can be rendered highly conformable to the concavoconvex shape of

the surface. Accordingly, upon smoothing, while imparting proper smoothness to fine concavoconvexes in the substrate concavoconvex layer which are completely collapsed in the conventional surface modifying layer, a certain level of concavoconvexes can be allowed to stay.

[0220] The term “colloidal silica” as used herein means a colloidal solution containing silica particles in a colloid state dispersed in water or an organic solvent. The particle diameter (diameter) of the colloidal silica is preferably approximately 1 to 50 nm which is on an ultrafine particle size level. The particle diameter of the colloidal silica in the present invention is the average particle diameter as measured by a BET method. The average particle diameter is specifically determined by measuring the surface area by the BET method and calculating the average particle diameter based on the assumption that the particles are truly spherical.

[0221] The colloidal silica is known, and commercially available products thereof include, for example, “methanol silica sol,” “MA-ST-M,” “IPA-ST,” “EG-ST,” “EG-ST-ZL,” “NPC-ST,” “DMAC-ST,” “MEK,” “XBA-ST,” and “MIBK-ST” (all of which are tradenames of products manufactured by Nissan Chemical Industries Ltd.), “OSCAL1132,” “OSCAL1232,” “OSCAL1332,” “OSCAL1432,” “OSCAL1532,” “OSCAL1632,” and “OSCAL1132” (all of which are tradenames of products manufactured by Catalysts and Chemicals Industries Co., Ltd.).

[0222] The content of the organic fine particles or inorganic fine particles is preferably 5 to 300 in terms of the mass of the fine particles based on 100 of the mass of the binder resin in the surface modifying layer (mass of fine particles/mass of binder resin=P/V ratio=5 to 300/100). When the addition amount falls within the above-defined range, the conformability to the concavoconvex shape is satisfactory. As a result, black color reproduction such as glossy black color feeling and anti-dazzling properties can be simultaneously realized. Further, properties such as adhesion and scratch resistance are improved. The addition amount may vary depending upon the fine particles added. For example, in the case of colloidal silica, the addition amount is preferably 5 to 80. When the addition amount falls within the above-defined range, the anti-dazzling properties and the adhesion to other layer(s) are improved.

[0223] Solvent

[0224] A composition for a surface modifying layer comprising the above components mixed with the solvent is utilized for surface modifying layer formation. The solvent may be selected and used depending upon the type and solubility of the polymer and the curable resin precursor, and any solvent may be used so far as it can homogeneously dissolve at least solid matter (a plurality of polymers and curable resin precursor, a reaction initiator, and other additives). Such solvents include, for example, ketones, for example, acetone, methyl ethyl ketone, methyl isobutyl ketone, and cyclohexanone; ethers, for example, dioxane and tetrahydrofuran; aliphatic hydrocarbons, for example, hexane; alicyclic hydrocarbons, for example, cyclohexane; aromatic hydrocarbons, for example, toluene and xylene; halogenated hydrocarbons, for example, dichloromethane and dichloroethane; esters, for example, methyl acetate, ethyl acetate, and butyl acetate; water; alcohols, for example, ethanol, isopropanol, butanol, and cyclohexanol; cellosolves, for example, methylcellosolve and ethylcellosolve, cellosolve acetates; sulfoxides, for example, dimethylsulfoxide; and amides, for example, dimethylformamide and dimethylacetamide. A mixture solvent

composed of two or more of these solvents may also be used. Preferred are ketones and esters.

[0225] Method for Surface Modifying Layer Formation

[0226] The surface modifying layer may be formed by applying a composition for a surface modifying layer onto the substrate concavoconvex layer. The composition for a surface modifying layer may be formed by coating methods such as roll coating, Mayer bar coating, or gravure coating. After coating of the composition for a surface modifying layer, the coating is dried and cured by ultraviolet light irradiation. Specific examples of ultraviolet light sources include ultra-high-pressure mercury lamps, high-pressure mercury lamps, low-pressure mercury lamps, carbon arc lamps, black light Fluorescent lamps, and metal halide lamps. Regarding the wavelength of the ultraviolet light, a wavelength range of 190 to 380 nm may be used. Specific examples of electron beam sources include various electron beam accelerators, for example, Cockcroft-Walton accelerators, van de Graaff accelerators, resonance transformer accelerators, insulated core transformer accelerators, linear accelerators, Dynamitron accelerators, and high-frequency accelerators.

[0227] 3. Optional Layers

[0228] The optical laminate according to the present invention comprises a light transparent base material and an anti-dazzling layer (or a concavoconvex substrate layer and a surface modifying layer). Optional layers such as an antistatic layer, a low-refractive index layer, and a contamination preventive layer may be further provided. The low-refractive index layer preferably has a lower refractive index than the refractive index of the anti-dazzling layer having a single layer structure or surface modifying layer. The refractive index of the low-refractive index layer is not more than 1.45, particularly preferably not more than 1.42. The thickness of the low-refractive index layer is not limited and may be generally properly selected from a range of approximately 30 nm to 1 μ m. The antistatic layer, low-refractive index layer, contamination preventive layer and the like may be formed by using a composition prepared by mixing a resin and the like with an antistatic agent, a low-refractive index agent, a contamination preventive agent or the like as described above in connection with the surface modifying layer. Accordingly, the antistatic agent, low-refractive index agent, contamination preventive agent, resin and the like may be the same as those used in the formation of the surface modifying layer.

[0229] 4. Light Transparent Base Material

[0230] The light transparent base material is preferably smooth and possesses excellent heat resistance and mechanical strength. Specific examples of materials usable for the light transparent base material formation include thermoplastic resins, for example, polyesters (for example, polyethylene terephthalate and polyethylene naphthalate), cellulosic resins (for example, cellulose triacetate, cellulose diacetate, and cellulose acetate butyrate), polyethersulfone, and polyolefins (for example, polysulfone, polypropylene, and polymethylpentene), polyvinyl chloride, polyvinylacetal, polyether ketone, acrylic resins (for example, polymethyl methacrylate), polycarbonate, and polyurethane. Preferred are polyesters (polyethylene terephthalate and polyethylene naphthalate) and cellulose triacetate. Films of amorphous olefin polymers (cycloolefin polymers: COPs) having an alicyclic structure may also be mentioned as other examples or the light transparent base material. These films are base materials using nobornene polymers, monocyclic olefinic polymers, cyclic conjugated diene polymers, vinyl alicyclic hydrocar-

bon polymer resins and the like, and examples thereof include Zeonex and ZEONOR, manufactured by Zeon Corporation (norbornene resins), Sumilight FS-1700 manufactured by Sumitomo Bakelite Co., Ltd., ARTON (modified norbornene resin) manufactured by JSR Corporation, APL (cyclic olefin copolymer) manufactured by Mitsui Chemicals Inc., Topas (cyclic olefin copolymer) manufactured by Ticona, and Optlet OZ-1000 series (alicyclic acrylic resins) manufactured by Hitachi Chemical Co., Ltd. Further, FV series (low birefringent index and low photoelastic films) manufactured by Asahi Kasei Chemicals Corporation are also preferred as base materials alternative to triacetylcellulose.

[0231] In the present invention, preferably, these thermoplastic resins are used as a highly flexible thin film. Depending upon the form of use where curability are required, plate-like materials such as plates of these thermoplastic resins or glass plates are also usable.

[0232] The thickness of the light transparent base material is not less than 20 μm and not more than 300 μm . Preferably, the upper limit of the thickness is 200 μm , and the lower limit of the thickness is 30 μm . When the light transparent base material is a plate-like material, the thickness may be above the upper limit of the above-defined thickness range. In this case, a thickness of about 1 to 5 mm is adopted. In forming an anti-dazzling layer on the light transparent base material, the base material may be previously subjected to physical treatment such as corona discharge treatment or oxidation treatment or may be previously coated with an anchoring agent or a coating material known as a primer from the viewpoint of improving the adhesion.

[0233] II. Utilization of Optical Laminate

[0234] The optical laminate produced by the process according to the present invention may be used in the following applications.

[0235] Polarizing Plate

[0236] In another embodiment of the present invention, there is provided a polarizing plate comprising a polarizing element and the optical laminate according to the present invention. More specifically, there is provided a polarizing plate comprising a polarizing element and the optical laminate according to the present invention provided on the surface of the polarizing element, the optical laminate being provided so that the surface of the optical laminate remote from the anti-dazzling layer faces the surface of the polarizing element. The polarizing element may comprise, for example, polyvinyl alcohol films, polyvinylformal films, polyvinylacetal films, and ethylene-vinyl acetate copolymer-type saponified films, which have been dyed with iodine or a dye and stretched. In the lamination treatment, preferably, the light transparent base material (preferably a triacetylcellulose film) is saponified from the viewpoint of increasing the adhesion or antistatic purposes.

[0237] Image Display Device

[0238] In a further embodiment of the present invention, there is provided an image display device. The image display device comprises a transmission display and a light source device for applying light to the transmission display from its back side. The optical laminate according to the present invention or the polarizing plate according to the present invention is provided on the surface of the transmission display. The image display device according to the present invention may basically comprise a light source device, a display element, and the optical laminate according to the present invention. The image display device is utilized in

transmission display devices, particularly in displays of televisions, computers, word processors and the like. Among others, the image display device is used on the surface of displays for high-definition images such as CRTs, PDPs, and liquid crystal panels.

[0239] When the image display device according to the present invention is a liquid crystal display device, light emitted from the light source device is applied through the lower side of the optical laminate according to the present invention. In STN-type liquid crystal display devices, a phase difference plate may be inserted into between the liquid crystal display element and the polarizing plate, if necessary, an adhesive layer may be provided between individual layers in the liquid crystal display device.

EXAMPLES

[0240] The following embodiments further illustrate the present invention. However, it should be noted that the contents of the present invention are not limited by these embodiments. The “parts” and “%” are by mass unless otherwise specified. All of monodisperse fine particles incorporated in the following compositions are those having a particle size distribution of average particle diameter ± 0.3 to ± 1 μm . In the case of fine particles having particle diameters of not more than 3.5 μm , however, this particle distribution is not applied.

[0241] Compositions for respective layers constituting an optical laminate were prepared according to the following formulations.

Preparation of Composition for Anti-Dazzling Layer

[0242] Composition 1 for Anti-Dazzling Layer (Example 9)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	21 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	9 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
First light transparent fine particles: monodisperse acrylic beads (particle diameter 4.6 μm , refractive index 1.535)	4.95 pts. mass
Second light transparent fine particles: styrene beads (particle diameter 3.5 μm , refractive index 1.60)	0.33 pt. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0132 pt. mass

[0243] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 42%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 1 for an anti-dazzling layer.

[0244] Composition 2 for Anti-Dazzling Layer (Example 11)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	19.5 pts. mass
Isocyanuric acid-modified diacrylate M215 (manufactured by TOAGOSEI Co., Ltd.)	10.5 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
First light transparent fine particles: monodisperse acrylic beads (particle diameter 9.0 μm , refractive index 1.535)	3.3 pts. mass
Second light transparent fine particles: styrene beads (particle diameter 3.5 μm , refractive index 1.60)	4.62 pt. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0132 pt. mass

[0245] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 60%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 2 for an anti-dazzling layer.

[0246] Composition 3 for Anti-Dazzling Layer (Comparative Example 1)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	19.5 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	10.5 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
Light transparent fine particles: monodisperse acrylic beads (particle diameter 3.5 μm , refractive index 1.535)	6.6 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0132 pt. mass

[0247] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 40.5%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 3 for an anti-dazzling layer.

[0248] Composition 4 for Anti-Dazzling Layer (Comparative Example 2)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	19.5 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	10.5 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
Light transparent fine particles: monodisperse acrylic beads (particle diameter 5.0 μm , refractive index 1.535)	6.6 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0132 pt. mass

[0249] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 40.5%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 4 for an anti-dazzling layer.

[0250] Composition 5 for Anti-Dazzling Layer (Comparative Example 3)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	19.5 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	10.5 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
Light transparent fine particles: Acrylic beads having a particle size distribution (particle diameter 5.0 $\mu\text{m} \pm 3.0$, refractive index 1.535)	6.6 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0132 pt. mass

[0251] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2, were added so that the total solid content was 40.5%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 5 for an anti-dazzling layer.

[0252] Composition 6 for Anti-Dazzling Layer (Comparative Examples 4, 5 and 6)

Urethane acrylate monomer UV 1700 B (refractive index 1.52)	30 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3 pts. mass

-continued

Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
Light transparent fine particles: monodisperse styrene beads (particle diameter 3.5 μm , refractive index 1.60)	6.6 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0132 pt. mass

[0253] The above materials and toluene as a solvent were added so that the total solid content was 40.0%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 6 for an anti-dazzling layer.

[0254] Composition 7 for Anti-Dazzling Layer (Comparative Example 7)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	18 pts. mass
Isocyanuric acid-modified diacrylate M215 (manufactured by TOAGOSEI Co., Ltd.)	1.2 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
Light transparent fine particles: monodisperse acrylic beads (particle diameter 5.0 μm , refractive index 1.53)	5.28 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0132 pt. mass

[0255] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 40.5%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 7 for an anti-dazzling layer.

[0256] Composition 8 for Anti-Dazzling Layer (Comparative Example 8)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	13.0 pts. mass
Isocyanuric acid-modified diacrylate M215 (manufactured by TOAGOSEI Co., Ltd.)	7.0 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	2 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.32 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.22 pt. mass

-continued

First light transparent fine particles: monodisperse acrylic beads (particle diameter 9.0 μm , refractive index 1.535)	4.4 pts. mass
Second light transparent fine particles: monodisperse styrene beads (particle diameter 3.5 μm , refractive index 1.60)	0.44 pt. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0077 pt. mass

[0257] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 40.5%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 8 for an anti-dazzling layer.

[0258] Composition 9 for Anti-Dazzling Layer (Comparative Example 9)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	28.4 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	1.50 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3.18 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.96 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
Light transparent fine particles: monodisperse styrene beads (particle diameter 3.5 μm , refractive index 1.60)	4.55 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0105 pt. mass

[0259] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 7:3 were added so that the total solid content was 38%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 9 for an anti-dazzling layer.

[0260] Composition 10 for Anti-Dazzling Layer (Comparative Example 10)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	12.0 pts. mass
Isocyanuric acid-modified diacrylate M215 (manufactured by TOAGOSEI Co., Ltd.)	8.0 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	2 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.32 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.22 pt. mass

-continued

First light transparent fine particles: monodisperse styrene-acrylic copolymer beads (particle diameter 3.5 μ m, refractive index 1.555)	4.84 pts. mass
Second light transparent fine particles: monodisperse styrene beads (particle diameter 3.5 μ m, refractive index 1.60)	0.55 pt. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0077 pt. mass

[0261] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 6:4 were added so that the total solid content was 38%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 10 for an anti-dazzling layer.

[0262] Composition 11 for Anti-Dazzling Layer (Comparative Example 14)

Ultraviolet curing resin: pentaerythritol triacrylate (PETA) (manufactured by Nippon kayaku Co., Ltd., refractive index 1.51)	30 pts. mass
Cellulose acetate propionate: CAP (molecular weight 50,000)	0.375 pt. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.82 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.30 pt. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.125 pt. mass
Light transparent fine particles: monodisperse polystyrene particles (manufactured by Soken Chemical Engineering Co., Ltd., particle diameter 3.5 μ m, refractive index 1.60)	2.73 pts. mass

[0263] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 7:3 were added so that the total solid content was 35%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 11 for an anti-dazzling layer.

[0264] Preparation of Composition for Substrate Concavoconvex Layer

[0265] Composition 1 for Substrate Concavoconvex Layer (Example 1)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	14 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	6 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	2 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.32 pts. mass

-continued

Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.22 pt. mass
First light transparent fine particles: styrene beads (particle diameter 5.0 μ m, refractive index 1.60)	0.64 pt. mass
Second light transparent fine particles: melamine beads (particle diameter 1.8 μ m, refractive index 1.68)	2.2 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0088 pt. mass

[0266] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 42%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 1 for a substrate concavoconvex layer.

[0267] Composition 2 for Substrate Concavoconvex Layer (Examples 2, 3, 4, 5, and 6)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	19.5 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	10.5 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
First light transparent fine particles: monodisperse acrylic beads (particle diameter 9.0 μ m, refractive index 1.535)	4.95 pts. mass
Second light transparent fine particles: styrene beads (particle diameter 3.5 μ m, refractive index 1.60)	6.6 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0132 pt. mass

[0268] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 40.5%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 2 for a substrate concavoconvex layer.

[0269] Composition 3 for Substrate Concavoconvex Layer (Example 7 and 8)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	19.5 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	10.5 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3 pts. mass

-continued

Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
First light transparent fine particles: monodisperse acrylic beads (particle diameter 7.0 μ m, refractive index 1.535)	6.6 pts. mass
Second light transparent fine particles: styrene beads (particle diameter 3.5 μ m, refractive index 1.60)	11.55 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0132 pt. mass

[0270] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 40.5%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 3 for a substrate concavoconvex layer.

[0271] Composition 4 for Substrate Concavoconvex Layer (Example 10)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	30 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
First light transparent fine particles: monodisperse acrylic beads (particle diameter 7.0 μ m, refractive index 1.535)	4.95 pts. mass
Second light transparent fine particles: styrene beads (particle diameter 3.5 μ m, refractive index 1.60)	5.445 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0132 pt. mass

[0272] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 40.5%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 4 for a substrate concavoconvex layer.

[0273] Composition 5 for Substrate Concavoconvex Layer (Example 12)

[0274] An amorphous silica matting agent dispersed ink (a resin (PETA) dispersion liquid of amorphous silica having an average particle diameter of 2.5 μ m; solid content: 60%; silica component: 15%, of total solid content; solvent: toluene) and pentaerythritol triacrylate (PETA) (refractive index 1.51) as an ultraviolet curing resin were used for preparing a composition comprising, based on 100 parts by mass in total of

PETA in the total solid content, 20 parts by mass of monodisperse acrylic beads (particle diameter 7.0 μ m, refractive index 1.535) as light transparent fine particles, 3.0 parts by mass of monodisperse styrene beads (particle diameter 3.5 μ m, refractive index 1.60), and 2.0 parts by mass of amorphous silica. Further, 0.04%, based on 100 parts by mass in total of the resin, of a silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.) was added so that the solid content of the final composition was 40.5% by weight. Furthermore, suitable amounts of toluene and cyclohexanone (toluene/cyclohexanone=8/2) were added, and the mixture was thoroughly mixed. The composition thus obtained was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 5 for a substrate concavoconvex layer.

[0275] Composition 6 for Substrate Concavoconvex Layer (Examples 13 and 14)

[0276] An amorphous silica matting agent dispersed ink (a resin (PETA) dispersion liquid of amorphous silica having an average particle diameter of 2.5 μ m; solid content: 60%; silica component: 15% of total solid content; solvent: toluene) and pentaerythritol triacrylate (PETA) (refractive index 1.51) as an ultraviolet curing resin were used for preparing a composition comprising, based on 100 parts by mass in total of PETA in the total solid content, 20 parts by mass of monodisperse acrylic beads (particle diameter 7.0 μ m, refractive index 1.535) as light transparent fine particles, 16.5 parts by mass of monodisperse styrene beads (particle diameter 3.5 μ m, refractive index 1.60), and 2.0 parts by mass of amorphous silica. Further, 0.04%, based on 100 parts by mass in total of the resin, of a silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.) was added so that the solid content of the final composition was 40.5% by weight. Furthermore, suitable amounts of toluene and cyclohexanone (toluene/cyclohexanone=8/2) were added, and the mixture was thoroughly mixed. The composition thus obtained was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 6 for a substrate concavoconvex layer.

[0277] Composition 7 for Substrate Concavoconvex Layer (Example 15)

[0278] An amorphous silica matting agent dispersed ink (a resin (PETA) dispersion liquid of amorphous silica having an average particle diameter of 2.5 μ m; solid content, 60%; silica component: 15% of total solid content; solvent: toluene) and pentaerythritol triacrylate (PETA) (refractive index 1.51) as an ultraviolet curing resin were used for preparing a composition comprising, based on 100 parts by mass in total of PETA in the total solid content, 20 parts by mass of monodisperse acrylic beads (particle diameter 7.0 μ m, refractive index 1.535) as light transparent fine particles, 8.5 parts by mass of monodisperse styrene beads (particle diameter 3.5 μ m, refractive index 1.60), and 2.0 parts by mass of amorphous silica. Further, 0.04%, based on 100 parts by mass in total of the resin, of a silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.) was added so that the solid content of the final composition was 40.5% by weight. Furthermore, suitable amounts of toluene and cyclohexanone (toluene/cyclohexanone=8/2) were added, and the mixture was thoroughly mixed. The composition thus obtained was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 7 for a substrate concavoconvex layer.

[0279] Composition 8 for Substrate Concavoconvex Layer (Example 16 and 17)

[0280] An amorphous silica matting agent dispersed ink (a resin (PETA) dispersion liquid or amorphous silica having an average particle diameter of 2.5 μm ; solid content: 60%; silica component: 15% of total solid content; solvent: toluene) and pentaerythritol triacrylate (PETA) (refractive index 1.51) as an ultraviolet curing resin were used for preparing a composition comprising, based on 100 parts by mass in total of PETA in the total solid content, 20 parts by mass of monodisperse acrylic beads (particle diameter 7.0 μm , refractive index 1.535) as light transparent fine particles, 2.5 parts by mass of monodisperse styrene beads (particle diameter 3.5 μm , refractive index 1.60), and 2.0 parts by mass of amorphous silica. Further, 0.04%, based on 100 parts by mass in total of the resin, of a silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.) was added so that the solid content of the final composition was 40.5% by weight. Furthermore, suitable amounts of toluene and cyclohexanone (toluene/cyclohexanone=8/2) were added, and the mixture was thoroughly mixed. The composition thus obtained was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 8 for a substrate concavoconvex layer.

[0281] Composition 9 for Substrate Concavoconvex Layer (Example 18)

[0282] An amorphous silica matting agent dispersed ink (a resin (PETA) dispersion liquid of amorphous silica having an average particle diameter of 2.5 μm ; solid content: 60%; silica component: 15% of total solid content; solvent: toluene) and pentaerythritol triacrylate (PETA) (refractive index 1.51) as an ultraviolet curing resin were used for preparing a composition comprising, based on 100 parts by mass in total of PETA in the total solid content, 20 parts by mass of monodisperse acrylic beads (particle diameter 7.0 μm , refractive index 1.535) as light transparent fine particles, 2.5 parts by mass of monodisperse styrene beads (particle diameter 3.5 μm , refractive index 1.60), and 1.0 parts by mass of amorphous silica. Further, 0.04%, based on 100 parts by mass in total of the resin, of a silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.) was added so that the solid content of the final composition was 40.5% by weight. Furthermore, suitable amounts of toluene and cyclohexanone (toluene/cyclohexanone=8/2) were added, and the mixture was thoroughly mixed. The composition thus obtained was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 9 for a substrate concavoconvex layer.

[0283] Composition 10 for Substrate Concavoconvex Layer (Example 19)

[0284] An amorphous silica matting agent dispersed ink (a resin (PETA) dispersion liquid of amorphous silica having an average particle diameter of 2.5 μm ; solid content: 60%; silica component: 15% of total solid content; solvent: toluene) and pentaerythritol triacrylate (PETA) (refractive index 1.51) as an ultraviolet curing resin were used for preparing a composition comprising, based on 100 parts by mass in total of PETA in the total solid content, 20 parts by mass of monodisperse acrylic beads (particle diameter 7.0 μm , refractive index 1.535) as light transparent fine particles, 2.5 parts by mass of monodisperse styrene beads (particle diameter 3.5 μm , refractive index 1.60), and 3.5 parts by mass of amorphous silica. Further, 0.04%, based on 100 parts by mass in total of the resin, of a silicone leveling agent 10-28 (manu-

factured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.) was added so that the solid content of the final composition was 40.5% by weight. Furthermore, suitable amounts of toluene and cyclohexanone (toluene/cyclohexanone=8/2) were added, and the mixture was thoroughly mixed. The composition thus obtained was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 10 for a substrate concavoconvex layer.

[0285] Composition 11 for Substrate Concavoconvex Layer (Example 20 and Comparative Example 11)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	13.0 pts. mass
Isocyanuric acid-modified diacrylate M215 (manufactured by TOAGOSEI Co., Ltd.)	7.0 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	2 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.32 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.22 pt. mass
First light transparent fine particles: monodisperse acrylic beads (particle diameter 13.5 μm , refractive index 1.535)	0.44 pt. mass
Second light transparent fine particles: monodisperse styrene beads (particle diameter 3.5 μm , refractive index 1.60)	0.88 pt. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0077 pt. mass

[0286] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 6:4 were added so that the total solid content was 38%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 11 for a substrate concavoconvex layer.

[0287] Composition 12 for Substrate Concavoconvex Layer (Example 21)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	13.0 pts. mass
Isocyanuric acid-modified diacrylate M215 (manufactured by TOAGOSEI Co., Ltd.)	7.0 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	2 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.32 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.22 pt. mass
First light transparent fine particles: monodisperse acrylic beads (particle diameter 13.5 μm , refractive index 1.535)	0.88 pt. mass
Second light transparent fine particles: monodisperse styrene beads (particle diameter 3.5 μm , refractive index 1.60)	0.88 pt. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0077 pt. mass

[0288] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 6:4 were added so that the total solid content was 38%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 12 for a substrate concavoconvex layer.

[0289] Composition 13 for Substrate Concavoconvex Layer (Example 22)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	27.53 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	1.50 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3.10 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.89 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.32 pt. mass
First light transparent fine particles: monodisperse styrene beads (particle diameter 5.0 μm , refractive index 1.60)	4.81 pts. mass
Second light transparent fine particles: monodisperse melamine beads (particle diameter 1.8 μm , refractive index 1.68)	4.81 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.0130 pt. mass

[0290] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 7:3 were added so that the total solid content was 38%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 13 for a substrate concavoconvex layer.

[0291] Composition 14 for Substrate Concavoconvex Layer (Comparative Example 12)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	32 pts. mass
Cellulose acetate propionate: CAP (molecular weight 50,000)	0.4 pt. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.92 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.32 pt. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.11 pt. mass
Light transparent fine particles: monodisperse polystyrene particles (particle diameter 3.5 μm , refractive index 1.60)	1.94 pts. mass

[0292] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 7:3 were added so that the total solid content was 38%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter hav-

ing a pore diameter of 30 μm to prepare composition 14 for a substrate concavoconvex layer.

[0293] Composition 15 for Substrate Concavoconvex Layer (Comparative Example 13)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	13.0 pts. mass
Isocyanuric acid-modified diacrylate M215 (manufactured by TOAGOSEI Co., Ltd.)	7.0 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	2 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.32 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.22 pt. mass
First light transparent fine particles: monodisperse acrylic beads (particle diameter 13.5 μm , refractive index 1.535)	0.88 pt. mass
Second light transparent fine particles: monodisperse styrene beads (particle diameter 3.5 μm , refractive index 1.60)	1.76 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.077 pt. mass

[0294] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 6:4 were added so that the total solid content was 38%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 15 for a substrate concavoconvex layer.

[0295] Composition 16 for Substrate Concavoconvex Layer (Comparative Example 15)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	20 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	2.0 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.32 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.22 pt. mass
First light transparent fine particles: monodisperse acrylic beads (particle diameter 9.0 μm , refractive index 1.535)	4.54 pts. mass
Second light transparent fine particles: monodisperse styrene beads (particle diameter 3.5 μm , refractive index 1.60)	6.17 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.09 pt. mass

[0296] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 8:2 were added so that the total solid content was 40%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition 16 for a substrate concavoconvex layer.

[0297] Composition 17 for Substrate Concavoconvex Layer (Example 23)

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	28.5 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	1.50 pts. mass
Polymethyl methacrylate (PMMA) (molecular weight 75,000)	3.0 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.98 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.33 pt. mass
First light transparent fine particles: monodisperse styrene beads (particle diameter 5.0 μ m, refractive index 1.60)	4.95 pts. mass
Second light transparent fine particles: monodisperse melamine beads (particle diameter 1.8 μ m, refractive index 1.68)	3.96 pts. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.115 pt. mass

[0298] The above materials and a mixed solvent composed mainly of toluene and cyclohexanone at a mixing ratio of 7:3 were added so that the total solid content was 38%. They were thoroughly mixed together to prepare a composition. This composition was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 17 for a substrate concavoconvex layer.

[0299] Preparation of Composition for Surface Modifying Layer**[0300]** Composition 1 for Surface Modifying Layer

UV1700B (manufactured by Nippon Synthetic Chemical Industry Co., Ltd., polyfunctional urethane acrylate, refractive index 1.51)	31.1 pts. mass
M315 (manufactured by TOAGOSEI CO., LTD.)	10.4 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	2.49 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.41 pt. mass
Contamination preventive agent: UT-3971 (manufactured by Nippon Synthetic Chemical Industry Co., Ltd.)	2.07 pts. mass
Toluene	48.0 pts. mass
Cyclohexanone	5.5 pts. mass

[0301] The above components were thoroughly mixed together, and the mixture was filtered through a polypropylene filter having a pore diameter of 10 μ m to prepare composition 1 for a surface modifying layer.

[0302] Composition 2 for Surface Modifying Layer

UV1700B (manufactured by Nippon Synthetic Chemical Industry Co., Ltd., refractive index 1.51)	31.1 pts. mass
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-continued

M315 (manufactured by TOAGOSEI CO., LTD.)	10.4 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	2.49 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.41 pt. mass
Contamination preventive agent: UT-3971 (manufactured by Nippon Synthetic Chemical Industry Co., Ltd.)	2.07 pts. mass
Toluene	525.18 pts. mass
Cyclohexanone	60.28 pts. mass

[0303] The above components were thoroughly mixed together to prepare a composition, and the composition was filtered through a polypropylene filter having a pore diameter of 10 μ m to prepare composition 2 for a surface modifying layer.

[0304] Composition 3 for Surface Modifying Layer

UV1700B (manufactured by Nippon Synthetic Chemical Industry Co., Ltd., refractive index 1.51)	31.1 pts. mass
M315 (manufactured by TOAGOSEI CO., LTD.)	10.4 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	0.49 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.41 pt. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.19 pt. mass
Toluene	48.0 pts. mass
Cyclohexanone	5.5 pts. mass

[0305] The above components were thoroughly mixed together, and the mixture was filtered through a polypropylene filter having a pore diameter of 10 μ m to prepare composition 3 for a surface modifying layer.

Composition 4 for Surface Modifying Layer**[0306]**

Antistatic agent: C-4456 S-7 (an ATO-containing electroconductive Ink, average particle diameter of ATO: 300 to 400 nm, solid content 45%)	21.6 pts. mass
Dipentaerythritol hexaacrylate (DPHA) (refractive index 1.51)	28.69 pts. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	1.56 pts. mass
MIBK (methyl isobutyl ketone)	33.7 pts. mass
Cyclohexanone	14.4 pts. mass

[0307] The above components were mixed together, and the mixture was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 4 for a surface modifying layer.

[0308] Composition 5 for surface Modifying Layer

[0309] Composition 5 for a surface modifying layer having the following formulation was prepared using a zirconia-containing coating composition (manufactured by JSR, tradename; "KZ 7973", a resin matrix having a refractive index of 1.69, solid content 50%) so that the resin matrix had a refractive index of 1.60.

Pentaerythritol triacrylate (PETA) (refractive index 1.51)	18.59 pts. mass
Zirconia (manufactured by JSR, zirconia contained in "KZ 7973" (tradename), average particle diameter 40 to 60 nm, refractive index 2.0) (for incorporation in an ultraviolet curing resin to develop a resin matrix)	17.18 pts. mass
Zirconia dispersant (manufactured by JSR, a zirconia dispersion stabilizer contained in "KZ 7973" (tradename))	1.22 pts. mass
Acrylic polymer (molecular weight 40,000)	0.94 pt. mass
Photocuring initiator: Irgacure 184 (manufactured by Ciba Specialty Chemicals, K.K.)	3.56 pts. mass
Photocuring initiator: Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.26 pt. mass
Silicone leveling agent 10-28 (manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.039 pt. mass
Toluene	14.34 pts. mass
Cyclohexanone	15.76 pts. mass
MEK	2.80 pts. mass

[0310] The above components were thoroughly mixed together, and the mixture was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 5 for a surface modifying layer.

[0311] Composition 6 for Surface Modifying Layer

Colloidal silica slurry (MIBK dispersion liquid); solid content: 40%, average particle diameter; 20 nm)	26.01 pts. mass
UV-1700B (ultraviolet curing resin; manufactured by Nippon Synthetic Chemical Industry Co., Ltd.)	23.20 pts. mass
Aronix M315 (ultraviolet curing resin; manufactured by TOAGOSEI CO., LTD.)	7.73 pts. mass
Irgacure 184 (photocuring initiator; manufactured by Ciba Specialty Chemicals, K.K.)	1.86 pts. mass
Irgacure 907 (photocuring initiator; manufactured by Ciba Specialty Chemicals, K.K.)	0.31 pt. mass
UT-3971 (contamination preventive agent; MIBK solution (solid content 30%); manufactured by Nippon Synthetic Chemical Industry Co., Ltd.)	1.55 pts. mass
Toluene	19.86 pts. mass
MIBK	15.56 pts. mass
Cyclohexanone	3.94 pts. mass

[0312] The above components were thoroughly mixed together, and the mixture was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 6 for a surface modifying layer.

[0313] Composition 7 for Surface Modifying Layer

Colloidal silica slurry (MIBK dispersion liquid); solid content: 40%, average particle diameter: 20 nm	26.01 pts. mass
UV-1700B (ultraviolet curing resin; manufactured by Nippon Synthetic Chemical Industry Co., Ltd.)	23.20 pts. mass
Aronix M315 (ultraviolet curing resin; manufactured by TOAGOSEI CO., LTD.)	7.73 pts. mass
Irgacure 184 (photocuring initiator; manufactured by Ciba Specialty Chemicals, K.K.)	1.86 pts. mass
Irgacure 907 (photocuring initiator; manufactured by Ciba Specialty Chemicals, K.K.)	0.31 pt. mass
Silicone 10-28 (silicone leveling agent; toluene solution (solid content 10%); manufactured by Dainichiseika Color & Chemicals Manufacturing Co., Ltd.)	0.14 pt. mass
Toluene	19.86 pts. mass
MIBK	15.56 pts. mass
Cyclohexanone	3.94 pts. mass

[0314] The above components were thoroughly mixed together, and the mixture was filtered through a polypropylene filter having a pore diameter of 30 μ m to prepare composition 7 for a surface modifying layer.

[0315] Preparation of Composition for Low-Refractive Index Layer**[0316]** Composition for Low-Refractive Index Layer

Fluororesin composition (tradename; "TM086", manufactured by JSR)	34.14 pts. mass
Photopolymerization initiator (tradename; "JUA701," manufactured by JSR)	0.85 pt. mass
MIBK	65 pts. mass

[0317] The above components were stirred, and the mixture was filtered through a polypropylene filter having a pore diameter of 10 μ m to prepare composition 1 for a low-refractive index layer.

[0318] Composition 2 for Low-Refractive Index Layer

[0319] The following components were stirred according to the following formulation, and the mixture was filtered through a polypropylene filter having a pore diameter of 10 μ m to prepare composition 2 for a low-refractive index layer.

Hollow silica slurry (IPA and MIBK dispersion liquid; solid content 20%, particle diameter 50 nm)	9.57 pts. mass
PET30 (ultraviolet curing resin; manufactured by Nippon Kayaku Co., Ltd.)	0.981 pt. mass
AR110 (fluoropolymer; MIBK solution (solid content 15%), manufactured by Daikin Industries, Ltd.)	6.53 pts. mass
Irgacure 369 (photocuring initiator; manufactured by Ciba Specialty Chemicals, K.K.)	0.069 pt. mass
X-22-164E (silicone leveling agent; manufactured by The Shin-Etsu Chemical Co., Ltd.)	0.157 pt. mass

-continued

Propylene glycol monomethyl ether (PGME)	28.8
	pts. mass
Methyl isobutyl ketone	53.9
	pts. mass

[0320] The above components were stirred, and the mixture was filtered through a polypropylene filter having a pore diameter of 10 μm to prepare composition 2 for a low-refractive index layer.

[0321] Composition 3 for Low-Refractive Index Layer

Surface treated silica sol (void-containing fine particles) (as 20% methyl isobutyl ketone solution)	14.3	pts. mass
Pentaerythritol triacrylate (PETA, refractive index 1.51)	1.95	pts. mass
Irgacure 907 (manufactured by Ciba Specialty Chemicals, K.K.)	0.1	pt. mass
Polyether-modified silicone oil TSF4460 (tradename, manufactured by GE Toshiba Silicone Co., Ltd.)	0.15	pt. mass
Methyl isobutyl ketone	83.5	pts. mass

[0322] The above components were stirred, and the mixture was filtered through a polypropylene filter having a pore diameter of 10 μm to prepare composition 3 for a low-refractive index layer.

[0323] Preparation of Composition for Antistatic Layer

[0324] The following components were stirred according to the following formulation, and was filtered through a polypropylene filter having a pore diameter of 30 μm to prepare composition for an antistatic layer.

Antistatic agent: C-4456 S-7 (an ATO-containing electroconductive ink, average particle diameter of ATO: 300 to 400 nm, solid content 45%, manufactured by NIPPON PELNOX CORP.)	2.0	pts. mass
Methyl isobutyl ketone	2.84	pts. mass
Cyclohexanone	1.22	pts. mass

[0325] Production of Optical Laminates

[0326] Each optical laminate was prepared as follows. Materials, formulations, and properties of the composition for an anti-dazzling layer or the composition for a substrate concavoconvex layer used in the production of optical laminates were as shown in Table 1.

Example 1

Formation of Substrate Concavoconvex Layer

[0327] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 1 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #10, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 14 mJ to cure the coating film and

thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.17 from that of the binder resin in the substrate concavoconvex layer.

[0328] Formation of Surface Modifying Layer

[0329] Composition 2 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #8, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 6.5 μm .

Example 2

Formation of Substrate Concavoconvex Layer

[0330] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 2 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #10, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0331] Formation of Surface Modifying Layer

[0332] Composition 1 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 13 μm .

Example 3

Formation of Substrate Concavoconvex Layer

[0333] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 2 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #10, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0334] Formation of Surface Modifying Layer

[0335] Composition 3 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate.

[0336] Formation of Low-Refractive Index Layer

[0337] Composition 1 for a low-refractive index layer was further coated onto the surface modifying layer with a wire-wound rod for coating (Mayer's bar) #4, and the coating was heat dried in an oven of 50° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 150 mJ to cure the coating film. Thus, about 100 nm-thick low-refractive index layer was formed to produce an anti-dazzling low-reflectance optical laminate. The total thickness of the anti-dazzling layer was about 13 μm .

Example 4

Formation of Antistatic Layer

[0338] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. The composition for an antistatic layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #7, and the coated transparent base material was heat dried in an oven of 50° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 30 mJ for half curing to cure the coating film. Thus, a 1 μm -thick antistatic layer was formed.

[0339] Formation of Substrate Concavoconvex Layer

[0340] Composition 2 for a substrate concavoconvex layer was coated onto the antistatic layer with a wire-wound rod for coating (Mayer's bar) #10, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0341] Formation of Surface Modifying Layer

[0342] Composition 3 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate.

[0343] Formation of Low-Refractive Index Layer

[0344] Composition 3 for a low-refractive index layer was further coated onto the surface modifying layer with a wire-wound rod for coating (Mayer's bar) #4, and the coating was heat dried in an oven of 50° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 150 mJ to cure the coating film,

Thus, about 100 nm-thick low-refractive index layer was formed to produce an anti-dazzling low-reflectance optical laminate. The laminate may have antistatic properties. The total thickness of the anti-dazzling layer was about 14 μm .

Example 5

Formation of Substrate Concavoconvex Layer

[0345] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 2 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #10, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 ml to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0346] Formation of Surface Modifying Layer

[0347] Composition 5 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 30 ml to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate.

[0348] Formation of Low-Refracting Index Layer

[0349] Composition 1 for a low-refractive index layer was further coated onto the surface modifying layer with a wire-wound rod for coating (Mayer's bar) #4, and the coating was heat dried in an oven of 50° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 150 ml to cure the coating film. Thus, about 100 nm-thick low-refractive index layer was formed to produce an anti-dazzling low-reflectance optical laminate. The total thickness of the anti-dazzling layer was about 13 μm .

Example 6

Formation of Substrate Concavoconvex Layer

[0350] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 2 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #10, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0351] Formation of Surface Modifying Layer

[0352] Composition 4 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to

evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 13 μm .

Example 7

Formation of Substrate Concavoconvex Layer

[0353] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 3 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention or scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0354] Formation of Surface Modifying Layer

[0355] Composition 4 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 11 μm .

Example 8

Formation of Substrate Concavoconvex Layer

[0356] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 3 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0357] Formation of Surface Modifying Layer

[0358] Composition 1 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate.

[0359] Formation of Low-Refractive Index Layer

[0360] Composition 3 for a low-refractive index layer was further coated onto the surface modifying layer with a wire-wound rod for coating (Mayer's bar) #4, and the coating was

heat dried in an oven of 50° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 150 mJ to cure the coating film. Thus, about 100 nm-thick low-refractive index layer was formed to produce an anti-dazzling low-reflectance optical laminate. The total thickness of the anti-dazzling layer was about 11 μm .

Example 9

Formation of Anti-Dazzling Layer

[0361] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 1 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #10, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the anti-dazzling layer. The total thickness of the anti-dazzling layer was about 4.5 μm .

Example 10

Formation of Substrate Concavoconvex Layer

[0362] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 4 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0363] Formation of Surface Modifying Layer

[0364] Composition 1 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 12 μm .

Example 11

Formation of Anti-Dazzling Layer

[0365] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 2 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #28, and the coated transparent base material was heat dried in an oven of

70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer. The total thickness of the anti-dazzling layer was about 27 μm .

Example 12

Formation of Substrate Concavoconvex Layer

[0366] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 5 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0367] Formation of Surface Modifying Layer

[0368] Composition 1 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 11 μm .

Example 13

Formation of Substrate Concavoconvex Layer

[0369] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 6 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0370] Formation of Surface Modifying Layer

[0371] Composition 6 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to

produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 11 μm .

Example 14

Formation of Substrate Concavoconvex Layer

[0372] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 6 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 ml to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0373] Formation of Surface Modifying Layer

[0374] Composition 7 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 30 ml to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate.

[0375] Formation of Low-Refractive Index Layer

[0376] Composition 2 for a low-refractive index layer was further coated onto the surface modifying layer with a wire-wound rod for coating (Mayer's bar) #4, and the coating was heat dried in an oven of 50° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 150 ml to cure the coating film. Thus, about 100 nm-thick low-refractive index layer was formed to produce an anti-dazzling low-reflectance optical laminate. The total thickness of the anti-dazzling layer was about 11 μm .

Example 15

Formation of Substrate Concavoconvex Layer

[0377] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 7 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0378] Formation of Surface Modifying Layer

[0379] Composition 6 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultra-

violet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 11 μm .

Example 16

Formation of Substrate Concavoconvex Layer

[0380] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 8 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0381] Formation of Surface Modifying Layer

[0382] Composition 6 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer on the base material was about 11 μm .

Example 17

Formation of Substrate Concavoconvex Layer

[0383] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 8 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0384] Formation of Surface Modifying Layer

[0385] Composition 7 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate.

[0386] Formation of Low-Refractive Index Layer

[0387] Composition 2 for a low-refractive index layer was further coated onto the surface modifying layer with a wire-wound rod for coating (Mayer's bar) #4, and the coating was heat dried in an oven of 50° C. for one min to evaporate the

solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 150 mJ to cure the coating film. Thus, about 100 nm-thick low-refractive index layer was formed to produce an anti-dazzling low-reflectance optical laminate. The total thickness of the anti-dazzling layer was about 11 μm .

Example 18

Formation of Substrate Concavoconvex Layer

[0388] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 9 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0389] Formation of Surface Modifying Layer

[0390] Composition 6 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 11 μm .

Example 19

Formation of Substrate Concavoconvex Layer

[0391] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 10 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0392] Formation of Surface Modifying Layer

[0393] Composition 6 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to

produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 11 μm .

Example 20

Formation of Substrate Concavoconvex Layer

[0394] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 11 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #14, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0395] Formation of Surface Modifying Layer

[0396] Composition 1 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 16 μm .

Example 21

Formation of Substrate Concavoconvex Layer

[0397] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 12 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #14, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer. In this case, the development of an internal diffusion effect and more effective prevention of scintillation could be realized by using fine particles having a maximum refractive index difference of 0.09 from that of the binder resin in the substrate concavoconvex layer.

[0398] Formation of Surface Modifying Layer

[0399] Composition 1 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 16 μm .

Example 22

[0400] Formation of Substrate Concavoconvex Layer

[0401] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 13 for a substrate concavoconvex layer was coated onto the transparent base

material with a wire-wound rod for coating (Mayer's bar) #14, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer.

[0402] Formation of Surface Modifying Layer

[0403] Composition 2 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #8, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 6.5 μm .

Example 23

Formation of Substrate Concavoconvex Layer

[0404] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 17 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #14, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 14 mJ to cure the coating film and thus to form a substrate concavoconvex layer.

[0405] Formation of Surface Modifying Layer

[0406] Composition 2 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #10, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 7.5 μm .

Comparative Example 1

Formation of Anti-Dazzling Layer

[0407] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 3 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 5 μm .

Comparative Example 7

Formation of Anti-Dazzling Layer

[0408] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 4 for an anti-daz-

zling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #36, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 38 μm .

Comparative Example 3

Formation of Anti-Dazzling Layer

[0409] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 5 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #10, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. In the laminate thus formed, the average particle size distribution was broad and, due to the influence of giant particles which are unevenly present, the concavoconvex shape was not uniform. Consequently, the laminate had a deteriorated scintillation property. The total thickness of the anti-dazzling layer was about 5 μm .

Comparative Example 4

Formation of Anti-Dazzling Layer

[0410] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 6 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #14, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 7 μm .

Comparative Example 5

Formation of Anti-Dazzling Layer

[0411] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 6 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #12, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 6 μm .

Comparative Example 6

Formation of Anti-Dazzling Layer

[0412] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as

a transparent base material. Composition 6 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #10, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 5 μm .

Comparative Example 7

Formation of Anti-Dazzling Layer

[0413] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 7 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #10, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 4.5 μm .

Comparative Example 6

Formation of Anti-Dazzling Layer

[0414] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 8 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #10, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 7 μm .

Comparative Example 9

Formation of Anti-Dazzling Layer

[0415] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 9 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #12, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration: not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 4.5 μm .

Comparative Example 10

Formation of Anti-Dazzling Layer

[0416] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 10 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #12, and the

coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 4.5 μm .

Comparative Example 11

Formation of Substrate Concavoconvex Layer

[0417] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 11 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #14, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer.

[0418] Formation of Surface Modifying Layer

[0419] Composition 1 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 16 μm .

Comparative Example 12

Formation of Substrate Concavoconvex Layer

[0420] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 14 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 14 mJ to cure the coating film and thus to form a substrate concavoconvex layer.

Formation of Surface Modifying Layer

[0421] Composition 1 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #20, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 13.5 μm .

Comparative Example 13

Formation of Substrate Concavoconvex Layer

[0422] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 15 for a substrate concavoconvex layer was coated onto the transparent base

material with a wire-wound rod for coating (Mayer's bar) #14, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer.

[0423] Formation of Surface Modifying Layer

[0424] Composition 1 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 16 μm .

Comparative Example 14

Formation of Anti-Dazzling Layer

[0425] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 11 for an anti-dazzling layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #8, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 3 μm .

Comparative Example 15

Formation of Substrate Concavoconvex Layer

[0426] An 80 μm -thick triacetylcellulose film (TD80U, manufactured by Fuji Photo Film Co., Ltd.) was provided as a transparent base material. Composition 16 for a substrate concavoconvex layer was coated onto the transparent base material with a wire-wound rod for coating (Mayer's bar) #20, and the coated transparent base material was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, ultraviolet light was applied at an exposure of 30 mJ to cure the coating film and thus to form a substrate concavoconvex layer.

[0427] Formation of Surface Modifying Layer

[0428] Composition 1 for a surface modifying layer was further coated onto the substrate concavoconvex layer with a wire-wound rod for coating (Mayer's bar) #12, and the coating was heat dried in an oven of 70° C. for one min to evaporate the solvent component. Thereafter, under nitrogen purge (oxygen concentration; not more than 200 ppm), ultraviolet light was applied at an exposure of 100 mJ to cure the coating film and thus to form a surface modifying layer to produce an anti-dazzling optical laminate. The total thickness of the anti-dazzling layer was about 16 μm .

[0429] Evaluation Test

[0430] The following evaluation tests were carried out. The results are shown in Table 2.

Evaluation 1

Optical Property Test and Surface Shape

[0431] For the optical laminates of Examples and Comparative Examples, the whole haze Ha value of the optical

laminate, the internal haze value H_i and surface haze H_s of the optical laminate, H_i/H_a value, Sm , θ_a , R_z , reflection γ value (5-degree reflection), and surface resistivity (electrical surface resistance) were measured according to the definition described in the present specification.

[0432] Measurement of Surface Resistivity

[0433] The surface resistivity value ($\Omega/\square$) was measured at an applied voltage of 1000 V with a surface resistivity measuring device (manufactured by Mitsubishi Chemical Corporation, product number; Hiresta IP MCP-HT260).

Evaluation 2

Glossy Black Feeling Test (Light Room Environment)

[0434] A crossed Nicol polarizing plate was applied onto each of the optical laminates of Example and Comparative Example on its side remote from the film. Sensory evaluation was carried out under three-wavelength fluorescence of 30 W (applied to the anti-dazzling layer face in a 45-degree direction), and glossy black feeling (reproduction of glossy black) was evaluated in detail according to the following criteria. The sensory evaluation was carried out by visual observation from 50 cm above the sample surface at an angle of about 45 degrees.

[0435] Evaluation Criteria

[0436] ○: Glossy black color could be reproduced.

[0437] Δ: Glossy black color could be somewhat reproduced but was unsatisfactory as a product.

[0438] x: Glossy back color could not be reproduced.

Evaluation 3

Glare Test

[0439] A black matrix pattern plate (105 ppl, 140 ppl) formed on a 0.7 mm-thick glass was placed on a viewer

manufactured by HAKUBA (light viewer 7000PRO) so that the pattern surface faced downward. The optical laminate film prepared above was placed thereon so that the concavoconvex face was on the air side. Glare was visually observed in a dark room while lightly pressing with a finger the edge of the film to prevent the lift of the film, and the results were evaluated.

[0440] Evaluation Criteria

[0441] ◎: No glare was observed at 140 ppl, and the anti-glareness was good.

[0442] ○: No glare was observed at 105 ppl, and the anti-glareness was good.

[0443] x: Glare was observed at 105 ppl, and the anti-glareness was poor.

Evaluation 4

Anti-Dazzling Property Evaluation Test

[0444] The backside of an optical laminate produced in the Examples and Comparative Examples was subjected to treatment for rendering the backside self-adhesive, and each of the treated optical laminates were applied to the black acrylic plate to prepare evaluation samples. A 20 mm-width black-and-white stripe plate was provided. An image of this stripe was caught in the sample (the sample face was inclined upward at an angle of about 30 degrees) at an angle of 20 degrees from a normal to the sample face, and the sample was observed. The illuminance of the sample face was 250 lx (luxes), and the brightness (white) of the stripe was 65 cd/m². The distance between the stripe plate and the sample was brought to 1.5 m, and the distance between the sample and the viewer was 1 m. The anti-dazzling property was evaluated in relationship with how the stripe was viewed by an observer as followed.

[0445] Evaluation Criteria

[0446] ○: Stripe could not be perceived.

[0447] x: Stripe could be perceived.

TABLE 1-1

*Particle size distribution of monodisperse fine particles is average particle diameter ± 0.3 to 1.0 μm .						
Light transparent fine particles				Binder		
	Average particle diameter	Material	Weight ratio per unit area between resin and particle	Refractive index	Addition amount of polymer (based on binder)	Monomer ratio
Ex. 1	A) 5.0 μm B) 1.8 μm Mixed particle system	A) St (styrene) B) Melamine	Total: 0.27 A) 0.12 B) 0.10	A) 1.60 B) 1.68	PMMA polymer 10 wt % (mw 75000)	PETA:DPHA = 70:30 wt %
Ex. 2	9.0 μm 3.5 μm Mixed particle system	9.0 μm -PMMA 3.5 μm -St	0.315 (9.0 μm -0.15 3.5 μm -0.20)	9.0 μm - n = 1.535 3.5 μm - n = 1.60	PMMA polymer 10 wt % (mw 75000)	PETA:DPHA = 65:35 wt %
Ex. 3	↓	↓	↓	↓	↓	↓
Ex. 4	↓	↓	↓	↓	↓	↓
Ex. 5	↓	↓	↓	↓	↓	↓
Ex. 6	↓	↓	↓	↓	↓	↓
Ex. 7	7.0 μm 3.5 μm	7.0 μm -PMMA 3.5 μm -St	0.55 (7.0 μm -0.20 3.5 μm -0.35)	7.0 μm - n = 1.535 3.5 μm - n = 1.60	↓	↓
Ex. 8	↓	↓	↓	↓	↓	↓
Ex. 9	A) 4.6 μm B) 3.5 μm Mixed particle system	4.6 μm -PMMA (Hydrophobic behavior) 3.5 μm -St	Total: 0.20 A) 0.15 B) 0.01	A) 1.53 B) 1.60	PMMA polymer 10 wt % (mw 75000)	PETA:DPHA = 70:30 wt %

TABLE 1-1-continued

*Particle size distribution of monodisperse fine particles is average particle diameter ± 0.3 to $1.0 \mu\text{m}$.						
Ex. 10	7.0 μm 3.5 μm Mixed particle system	7.0 μm -PMMA 3.5 μm -St	Total: 0.315 (7.0 μm -0.15 3.5 μm -0.165)	7.0 μm - n = 1.535 3.5 μm - n = 1.60	PMMA polymer 10 wt % (mw 75000)	PETA 100%
Ex. 11	9.0 μm 3.5 μm Mixed particle system	9.0 μm -PMMA 3.5 μm -St	Total: 0.24 (9.0 μm -0.1 3.5 μm -0.14)	9.0 μm - n = 1.535 3.5 μm - n = 1.60	PMMA polymer 10 wt % (mw 75000)	PETA:M215 = 65:35 wt %
Ex. 12	7.0 μm 3.5 μm 2.5 μm Mixed particle system	7.0 μm -PMMA 3.5 μm -St 2.5 μm -Silica	Total: 0.25 (7.0 μm -0.2 3.5 μm -0.03 2.5 μm -0.02)	7.0 μm - r = 1.635 3.5 μm - n = 1.60 2.5 μm - n = 1.47 to 1.50	PMMA polymer 10 wt % (mw 75000)	PETA 100%
Ex. 13	7.0 μm 3.5 μm 2.5 μm Mixed particle system	7.0 μm -PMMA 3.5 μm -St 2.5 μm -Silica	Total: 0.385 (7.0 μm -0.2 3.5 μm -0.165 2.5 μm -0.02)	7.0 μm - n = 1.535 3.5 μm - n = 1.60 2.5 μm - n = 1.47 to 1.50	PMMA polymer 10 wt % (mw 75000)	PETA 100%
Ex. 14	↓	↓	↓	↓	↓	↓
Ex. 15	↓	↓	Total: 0.305 (7.0 μm -0.2 3.5 μm -0.085 2.5 μm -0.02)	↓	↓	↓
Ex. 16	↓	↓	Total: 0.245 (7.0 μm -0.2 3.5 μm -0.025 2.5 μm -0.02)	↓	↓	↓
Ex. 17	↓	↓	↓	↓	↓	↓
Ex. 18	↓	↓	Total: 0.235 (7.0 μm -0.2 3.5 μm -0.025 2.5 μm -0.01)	↓	↓	↓
Ex. 19	↓	↓	Total: 0.26 (7.0 μm -0.2 3.5 μm -0.025 2.5 μm -0.035)	↓	↓	↓
Ex. 20	13.50 μm 3.5 μm Mixed particle system	13.5 μm -PMMA 3.5 μm -St	Total: 0.05 (13.5 μm -0.20 3.5 μm -0.04)	13.5 μm - n = 1.535 3.5 μm - n = 1.60	PMMA polymer 10 wt % (mw 75000)	PETA:M215 = 65:35 wt %
Ex. 21	↓	↓	Total: 0.08 (13.5 μm -0.04 3.5 μm -0.04)	↓	↓	↓
Ex. 22	A) 5.0 μm B) 1.8 μm Mixed particle system	A) St (styrene) B) Melamine	Total: 0.3 A) 0.15 B) 0.15	A) 1.60 B) 1.68	PMMA polymer 10 wt % (mw 75000)	PETA:DPHA = 95:5 wt %
Ex. 23	A) 5.0 μm B) 1.8 μm Mixed particle system	A) St (styrene) B) Melamine	Total: 0.27 A) 0.15 B) 0.12	A) 1.60 B) 1.68	PMMA polymer 10 wt % (mw 75000)	PETA:DPHA = 95:5 wt %

	Binder Refractive index	Solvent composition (Ratio of toluene to coating composition component)	Difference in refractive index between light transparent fine particles and binder
Ex. 1	1.51	Toluene:cyclohexanone = 80:20 wt % (42.0 wt %)	0.09 0.17
Ex. 2	1.51	Toluene:cyclohexanone = 80:20 wt % (40.5 wt %)	0.025 0.09
Ex. 3	↓	↓	↓
Ex. 4	↓	↓	↓
Ex. 5	↓	↓	↓
Ex. 6	↓	↓	↓
Ex. 7	↓	↓	↓

TABLE 1-1-continued

*Particle size distribution of monodisperse fine particles is average particle diameter ± 0.3 to $1.0 \mu\text{m}$.				
Ex. 8	↓	↓	↓	↓
Ex. 9	1.51	Toluene:cyclohexanone = 80:20 wt % (42.0 wet %)	0.02 0.09	
Ex. 10	1.51	Toluene:cyclohexanone = 80:20 wt % (40.5 wet %)	0.025 0.09	
Ex. 11	1.51	Toluene:cyclohexanone = 80:20 wt % (60 wet %)	0.025 0.09	
Ex. 12	1.51	Toluene:cyclohexanone = 80:20 wt % (40.5 wet %)	0.025 0.09	0.01 to 0.04
Ex. 13	1.51	Toluene:cyclohexanone = 80:20 wt % (40.5 wet %)	0.025 0.09	0.01 to 0.04
Ex. 14	↓	↓	↓	↓
Ex. 15	↓	↓	↓	↓
Ex. 16	↓	↓	↓	↓
Ex. 17	↓	↓	↓	↓
Ex. 18	↓	↓	↓	↓
Ex. 19	↓	↓	↓	↓
Ex. 20	1.51	Toluene:cyclohexanone = 60:40 wt % (38.0 wet %)	0.025 0.09	
Ex. 21	↓	↓		
Ex. 22	1.51	Toluene:cyclohexanone = 70:30 wt % (38.0 wet %)	0.09 0.17	
Ex. 23	1.51	Toluene:cyclohexanone = 70:30 wt % (38.0 wet %)	0.09 0.17	

TABLE 1-2

Light transparent fine particles					Binder
	Average particle diameter	Material	Weight ratio per unit area between resin and particle	Refractive index	Addition amount of polymer (based on binder)
Comp. Ex. 2	5	↓	↓	↓	↓
Comp. Ex. 3	5 ± 3.0 (Particle size distribution)	↓	↓	↓	↓
Comp. Ex. 4	3.5	St	—	1.50	↓
Comp. Ex. 5	↓	↓	—	↓	↕
Comp. Ex. 6	↓	↓	—	↓	↕
Comp. Ex. 7	3.5 μm	PMMA	0.16	n = 1.535	PMMA polymer 10 wt % (mw 75000)
Comp. Ex. 8	9.0 μm 3.5 μm Mixed particle system	9.0 μm-PMMA 3.5 μm-St	Total: 0.22 (9.0 μm-0.22 3.5 μm-0.02)	9.0 μm-n = 1.535 3.5 μm-n = 1.60	PMMA polymer 10 wt % (mw 75000)
Comp. Ex. 9	3.5 μm	St	0.14	n = 1.6	PMMA polymer 10 wt % (mw 75000)
Comp. Ex. 10	3.5 μm Two-types particles mixed system	A) PMMA-St B) St	Total: 0.245 (A) 0.22 B) 0.025)	A): n = 1.555 B): n = 1.6	PMMA polymer 10 wt % (mw 75000)

TABLE 1-2-continued

Comp. Ex. 11	13.50 μm 3.5 μm Mixed particle system	13.5 μm -PMMA 3.5 μm -St	Total: 0.06 (13.5 μm -0.22 3.5 μm -0.04)	13.5 μm -n = 1.535 3.5 μm -n = 1.60	PMMA polymer 10 wt % (mw 75000)
Comp. Ex. 12	3.5 μm	St	0.05	n = 1.5	CAP 1.25 wt %
Comp. Ex. 13	13.50 μm 3.5 μm Mixed particle system	13.5 μm -PMMA 3.5 μm -St	Total: 0.12 (13.5 μm -0.04 3.5 μm -0.08)	13.5 μm -n = 1.535 3.5 μm -n = 1.60	PMMA polymer 10 wt % (mw 75000)
Comp. Ex. 14	3.5 μm	St	0.09	n = 1.6	CAP 1.25 wt %
Comp. Ex. 15	9.0 μm 3.5 μm Mixed particle system	9.0 μm -PMMA 3.5 μm -St	Total: 0.48 (9.0 μm -0.2 3.5 μm -0.28)	9.0 μm -n = 1.535 3.5 μm -n = 1.60	PMMA polymer 10 wt % (mw 75000)
		Binder	Refractive index	Solvent composition (Ratio of toluene to coating coating)	Difference in refractive index between light transparent fine particles and binder
		Monomer ratio		composition component)	
Comp. Ex. 2	↓	↓	↓	↓	↓
Comp. Ex. 3	↓	↓	↓	↓	↓
Comp. Ex. 4	UV17003 Urethan acrylate	1.52	Toluene (40 wet %)	0.08	
Comp. Ex. 5	↓	↓	↓	↓	↓
Comp. Ex. 6	↓	↓	↓	↓	↓
Comp. Ex. 7	PETA:M215 = 60:40 wt %	1.51	Toluene:cyclohexanone = 80:20 wt % (40.5 wet %)	0.025	
Comp. Ex. 8	PETA:M215 = 65:35 wt %	1.51	Toluene:cyclohexanone = 80:20 wt % (40.5 wet %)	0.025 0.09	
Comp. Ex. 9	PETA:MPHA = 95:5 wt %	1.51	Toluene:cyclohexanone = 70:30 wt % (38.0 wet %)	0.09	
Comp. Ex. 10	PETA:M215 = 60:40 wt %	1.51	Toluene:cyclohexanone = 60:40 wt % (38.0 wet %)	0.045 0.09	
Comp. Ex. 11	PETA:M215 = 65:35 wt %	1.51	Toluene:cyclohexanone = 60:40 wt % (38.0 wet %)	0.025 0.09	
Comp. Ex. 12	PETA = 100 wt %	1.51	Toluene:cyclohexanone = 70:30 wt % (38.0 wet %)	0.09	
Comp. Ex. 13	PETA:M215 = 65:35 wt %	1.51	Toluene:cyclohexanone = 60:40 wt % (38.0 wet %)	0.025 0.09	
Comp. Ex. 14	PETA = 100 wt %	1.51	Toluene:cyclohexanone = 70:30 wt % (35.0 wet %)	0.09	
Comp. Ex. 15	PETA = 100 wt %	1.51	Toluene:cyclohexanone = 80:20 wt % (40 wet %)	0.025 0.09	

TABLE 2

	Evaluation 1								Electrical surface resistance	Evaluation 2	Evaluation 3	Evaluation 4
	Hi/Ha	Ha (%)	Hi (%)	Hs (%)	Sm	Oa	Rz	Reflection Y value				
Ex. 1	0.93	56.0	52.1	3.9	165	0.40	0.54	— (* Ilo low- refractive index layer: 4%)	— (*Artistic layer; overrange for antistatic layer- free product)	○	⊙	○
Ex. 2	0.95	31.3	30.3	1.0	161	0.65	0.72	—	—	○	⊙	○
EX. 3	0.97	30.6	30.0	0.8	185	0.52	0.51	2.4%	—	○	⊙	○
Ex. 4	0.97	32.0	31.1	0.9	187	0.54	0.39	1.9%	3.2×10^{12}	○	⊙	○
Ex. 5	0.97	34.5	33.6	0.9	150	0.48	0.58	0.9%	—	○	⊙	○
Ex. 6	0.95	35.1	33.3	1.8	143	0.70	0.77	—	20×10^{12}	○	⊙	○
EX. 7	0.04	40.1	38.5	1.6	104.6	1.18	1.183	—	20×10^{12}	○	⊙	○
EX. 8	0.98	38.8	38.2	0.6	106	1.16	1.179	1.8%	—	○	⊙	○
Ex. 9	0.85	1.4	1.2	0.2	119	0.42	0.70	—	—	○	⊙	○
Ex. 10	0.99	26.8	26.5	0.3	212	0.47	0.66	—	—	○	⊙	○
Ex. 11	0.85	31.2	26.5	4.7	110	1.1	1.1	—	—	○	⊙	○
Ex. 12	0.90	5.0	4.5	0.5	170	0.52	0.75	—	—	○	⊙	○
Ex. 13	0.95	28.3	25.9	1.4	65	0.49	0.56	—	—	○	⊙	○
Ex. 14	0.98	27.5	27	0.5	72	0.37	0.27	1.2%	—	○	⊙	○
Ex. 15	0.90	15.5	14	1.5	102	0.56	0.64	—	—	○	⊙	○
Ex. 16	0.85	5.9	5	0.9	92	0.41	0.54	—	—	○	⊙	○
Ex. 17	0.93	5.4	5	0.4	103	0.33	0.21	1.2%	—	○	⊙	○
Ex. 18	0.85	6.8	5.6	1.0	130	0.73	0.59	—	—	○	⊙	○
Ex. 19	0.83	6.3	5.2	1.1	77	0.45	0.55	—	—	○	⊙	○
Ex. 20	0.94	7.2	6.6	0.4	360	0.54	1.04	—	—	○	⊙	○
Ex. 21	0.93	7.4	6.9	0.5	480	0.42	0.81	—	—	○	⊙	○
Ex. 22	0.99	85	84	1.0	162	0.42	0.5	—	—	○	⊙	○
Ex. 23	0.96	73.5	72	1.5	150	0.43	0.52	—	—	○	⊙	○
Comp. Ex. 1	0.99	18.6	0.1	18.5	65.2	1.892	1.213	—	—	X	X	○
Comp. Ex. 2	0.60	0.5	0.2	0.3	720.4	0.393	0.611	—	—	○	○	X
Comp. Ex. 3	1.00	22.4	0.1	22.3	82.3	2.135	1.451	—	—	X	X	○
Comp. Ex. 4	0.69	38.2	26.4	11.8	77	1.38	1.29	—	—	X	⊙	○
Comp. Ex. 5	0.64	44.0	28.3	15.7	91	1.95	2.0	—	—	X	⊙	○
Comp. Ex. 6	0.59	41.1	24.4	16.7	87	2.01	1.9	—	—	X	⊙	○
Comp. Ex. 7	0.25	5.0	1.2	3.8	88	1.7	1.1	—	—	X	X	○
Comp. Ex. 8	0.10	85	6	59.0	56	8.8	3.4	—	—	X	○	○
Comp. Ex. 9	0.73	36.5	27	9.5	77	1.7	1.5	—	—	X	⊙	○
Comp. Ex. 10	0.54	28	15	13.0	70	1.2	1.5	—	—	X	○	○
Comp. Ex. 11	0.93	6.4	6	0.4	650	0.31	0.52	—	—	○	X	X
Comp. Ex. 12	1.00	10	10	0.0	58	0.04	0.26	—	—	○	○	X
Comp. Ex. 13	0.90	11	10	1.0	553	0.56	1.7	—	—	○	X	X
Comp. Ex. 14	0.55	29	16	13.0	34	2.2	1.1	—	—	X	○	○
Comp. Ex. 15	0.98	94.7	92	1.7	510	0.95	1.18	—	—	X White	⊙	X

1. An optical laminate comprising a light transparent base material and an anti-dazzling layer provided on the light transparent base material, wherein

the outermost surface of the anti-dazzling layer has a concavoconvex shape, and

the optical laminate satisfies the following requirements:

Ha is more than 0% and less than 90%,

Hi is more than 0% and less than 90%, and Hi/Ha is not less than 0.8 and less than 1.0,

wherein Ha represents the whole haze value of the optical laminate; and Hi represents the internal haze value of the optical laminate.

2. The optical laminate according to claim 1, which has an Hs value of not less than 0.1 and less than 6.0 wherein Hs represents the surface haze of the optical laminate.

3. The optical laminate according to claim 1, wherein Sm is not less than 50 μm and not more than 500 μm , Oa is not less than 0.1 degree and not more than 1.2 degrees, and

Rz is more than 0.2 μm and not more than 1.2 μm ,

wherein Sm represents the average spacing of concavoconvexes in the anti-dazzling layer; Oa represents the average inclination angle of the concavoconvexes; and Rz represents the average roughness of the concavoconvexes.

4. The optical laminate according to claim 1, wherein the anti-dazzling layer comprises a resin and fine particles.

5. The optical laminate according to claim 4, wherein the difference n in refractive index between the resin and the fine particles is more than 0 and not more than 0.2.

6. The optical laminate according to claim 5, wherein the lower limit value of the difference n in refractive index between the resin and the fine particles is not less than 0.05.

7. The optical laminate according to claim 4, wherein the difference n in refractive index between the resin and the fine particles is more than 0 and not more than 0.05.

8. The optical laminate according to claim 4, wherein the fine particles are inorganic fine particles or organic fine particles.

9. The optical laminate according to claim 4, wherein the fine particles are aggregation-type fine particles.

10. The optical laminate according to claim 4, wherein the fine particles have an average particle diameter R of not less than 1.0 μm and not more than 20 μm .

11. The optical laminate according to claim 4, wherein 80% of the total number of the fine particles has an average particle diameter distribution of $R \pm 1.0 \mu\text{m}$ wherein R represents the average particle diameter of the fine particles.

12. The optical laminate according to claim 4, wherein the fine particles and the resin satisfy a requirement for the total weight ratio per unit area between the fine particles and the resin of m/M =not less than 0.01 and not more than 1.2 wherein m represents the total weight per unit area of the fine particles; and M represents the total weight of the resin per unit area.

13. The optical laminate according to claim 4, wherein the fine particles are of two or more types.

14. The optical laminate according to claim 4, wherein the resin comprises an ionizing radiation curing resin and a heat curing resin.

15. The optical laminate according to claim 1, wherein the anti-dazzling layer further comprises one material or a mixture of two or more materials selected from the group consisting of electroconductive agents, refractive index regulators, contamination inhibitors, water repellents, oil repellents, fingerprint adhesion preventive agents, highly curing agents, and hardness regulators.

16. The optical laminate according to claim 15, wherein the electroconductive agent is electroconductive fine particles or an electroconductive polymer.

17. The optical laminate according to claim 1, wherein the anti-dazzling layer comprises a surface modifying layer provided on the surface of a substrate concavoconvex layer.

18. The optical laminate according to claim 17, wherein the surface modifying layer comprises one material or a mixture of two or more materials selected from the group consisting of

antistatic agents, refractive index regulators, contamination inhibitors, water repellents, oil repellents, fingerprint adhesion preventive agents, highly curing agents, and hardness regulators.

19. The optical laminate according to claim 1, wherein the anti-dazzling layer has on its surface a low-refractive index layer having a lower refractive index than the refractive index of the anti-dazzling layer, and

the refractive index of the low-refractive index layer is lower than the refractive index of the surface modifying layer.

20. A polarizing plate comprising a polarizing element, wherein the polarizing element has an optical laminate according to claim 1 provided on the surface of the polarizing element, the optical laminate being provided so that the surface of the optical laminate remote from the anti-dazzling layer faces the surface of the polarizing element.

21. An image display device comprising: a transmission display; and a light source device for applying light to the transmission display from its backside, wherein

an optical laminate according to claim 1 is provided on the surface of the transmission display.

22. The optical laminate according to claim 1, which is applied on the outermost surface of a cathode-ray tube display device (CRT), a plasma display (PDP), an electroluminescent (ELD), or a liquid crystal display (LCD).

23. The optical laminate according to claim 1, wherein the anti-dazzling layer has been formed by applying a composition for an anti-dazzling layer onto the surface of the light transparent base material.

24. The optical laminate according to claim 1, wherein the anti-dazzling layer has been formed by applying a composition for an anti-dazzling layer onto the surface of the light transparent base material and curing the coating.

* * * * *